

Combined Analysis of thin structures: structure, microstructure, texture, stresses, phase, nanocrystals ...

at once in a single approach !

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Structure determination on real (textured) samples

Problem 1

Structure and QTA: correlations ?

$f(g)$ and $|F_h|^2$ are different !

$f(g)$:

- Angularly constrained: $[h_1 k_1 l_1]^*$ and $[h_2 k_2 l_2]^*$ make a given angle: more determined if F^2 high
- lot of data (spectra) needed

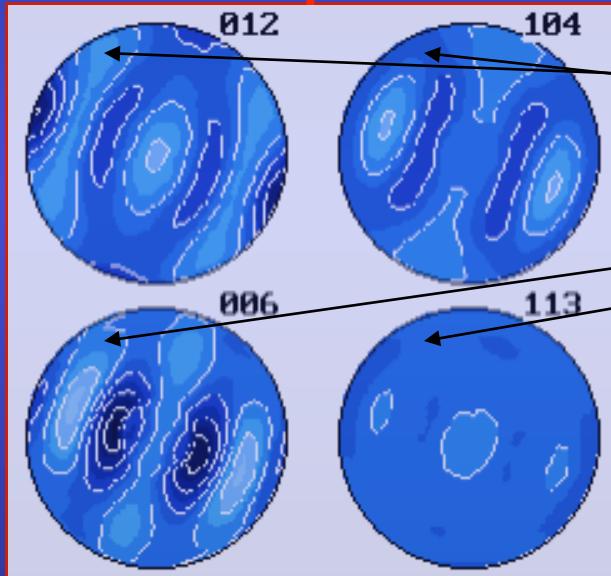
$|F_h|^2$:

- Position, f_i , and Debye-Waller constrained
- work on the sum of all diagrams on average

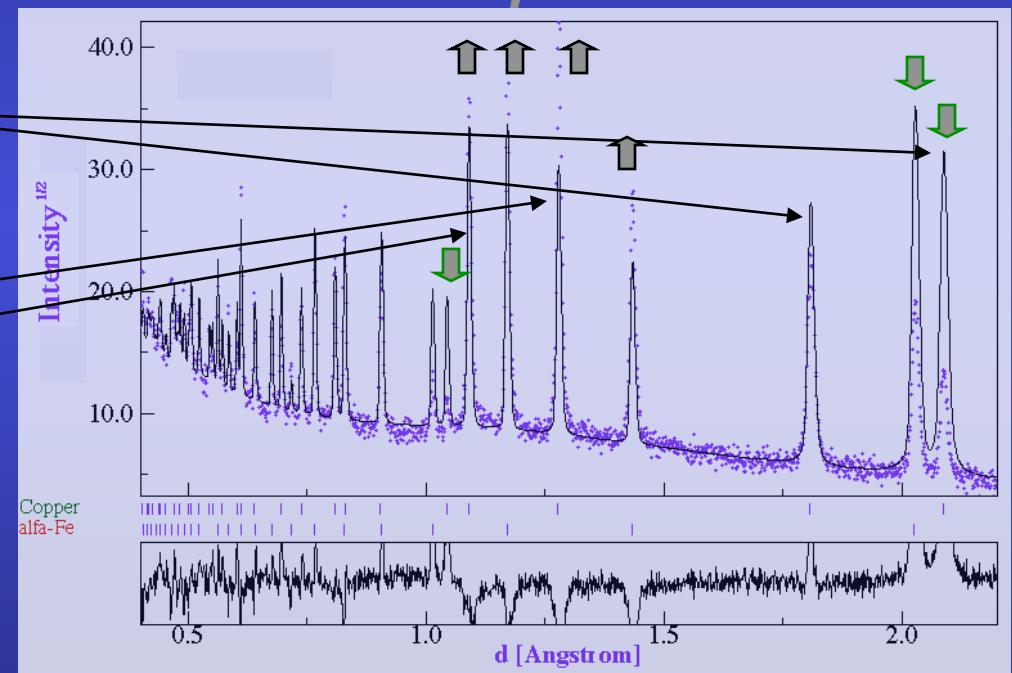
Texture from Spectra

Orientation Distribution Function (ODF)

From pole figures



From spectra



Le Bail extraction + ODF: WMV, E-WIMV, Generalized spherical harmonics, components, ADC, entropy maximisation ...

Why not benefit of texture in Structure determination ?

Perfect powders:

- overlaps (intra- and inter-)
- no angular constrain
- anisotropy difficult to resc

Single pattern

Single crystals:

- reduced overlaps
- max angular constrains

Many individual diffracted peaks

Textured powders:

- reduced overlaps
- angular constrain = $f(\text{texture strength})$
- Intermediate anisotropy

Many patterns to measure and analyse

Rietveld-Structure

$$y_c(\mathbf{y}_S, \theta, \eta) = y_b(\mathbf{y}_S, \theta, \eta) + I_0 \sum_{i=1}^{N_L} \sum_{\Phi=1}^{N_\Phi} \frac{v_{i\Phi}}{V_{c\Phi}^2} \sum_h L_p(\theta) j_{\Phi h} |F_{\Phi h}|^2 \Omega_{\Phi h}(\mathbf{y}_S, \theta, \eta) P_{\Phi h}(\mathbf{y}_S, \theta, \eta) A_{i\Phi}(\mathbf{y}_S, \theta, \eta)$$

Texture

$$P_k(\chi, \phi) = \int_{\varphi} f(g, \varphi) d\varphi$$

- Generalized Spherical Harmonics (Bunge):

$$P_k(\chi, \phi) = \sum_{l=0}^{\infty} \frac{1}{2l+1} \sum_{n=-l}^l k_l^n(\chi, \phi) \sum_{m=-l}^l C_l^{mn} k_n^{*m}(\Theta_k \phi_k)$$

$$f(g) = \sum_{l=0}^{\infty} \sum_{m,n=-l}^l C_l^{mn} T_l^{mn}(g)$$

- Components (Helming):

$$f(g) = F + \sum_c I^c f^c(g)$$

- WIMV (William, Imhof, Matthies, Vinel) iterative process:

$$f^{n+1}(g) = N_n \frac{f^n(g)f^0(g)}{\left(\prod_{h=1}^I \prod_{m=1}^{M_h} P_h^n(y) \right)^{\frac{1}{IM_h}}}$$

$$f^0(g) = N_0 \left(\prod_{h=1}^I \prod_{m=1}^{M_h} P_h^{\text{exp}}(y) \right)^{\frac{1}{IM_h}}$$

E-WIMV (Rietveld only):

with $0 < r_n < 1$, relaxation parameter,
 M_h number of division points of the integral
around k ,
 w_h reflection weight

- Entropy maximisation (Schaeben):

$$f^{n+1}(g) = f^n(g) \prod_{m=1}^{M_h} \left(\frac{P_h(y)}{P_h^n(y)} \right)^{r_n \frac{w_h}{M_h}}$$

- arbitrarily defined cells (ADC, Pawlik): Very similar to E-WIMV, with integrals along path tubes

$$f^{n+1}(g) = f^n(g) \prod_{m=1}^{M_h} \left(\frac{P_h(y)}{P_h^n(y)} \right)^{\frac{r_n}{M_h}}$$

Residual Stresses shift peaks with y

Problem 2

Stress and QTA: correlations ? $f(g)$ and $\langle C_{ijkl} \rangle$

$f(g)$:

- Moves the $\sin^2\Psi$ law away from linear relationship
- Needs the integrated peak (full spectra)

strains:

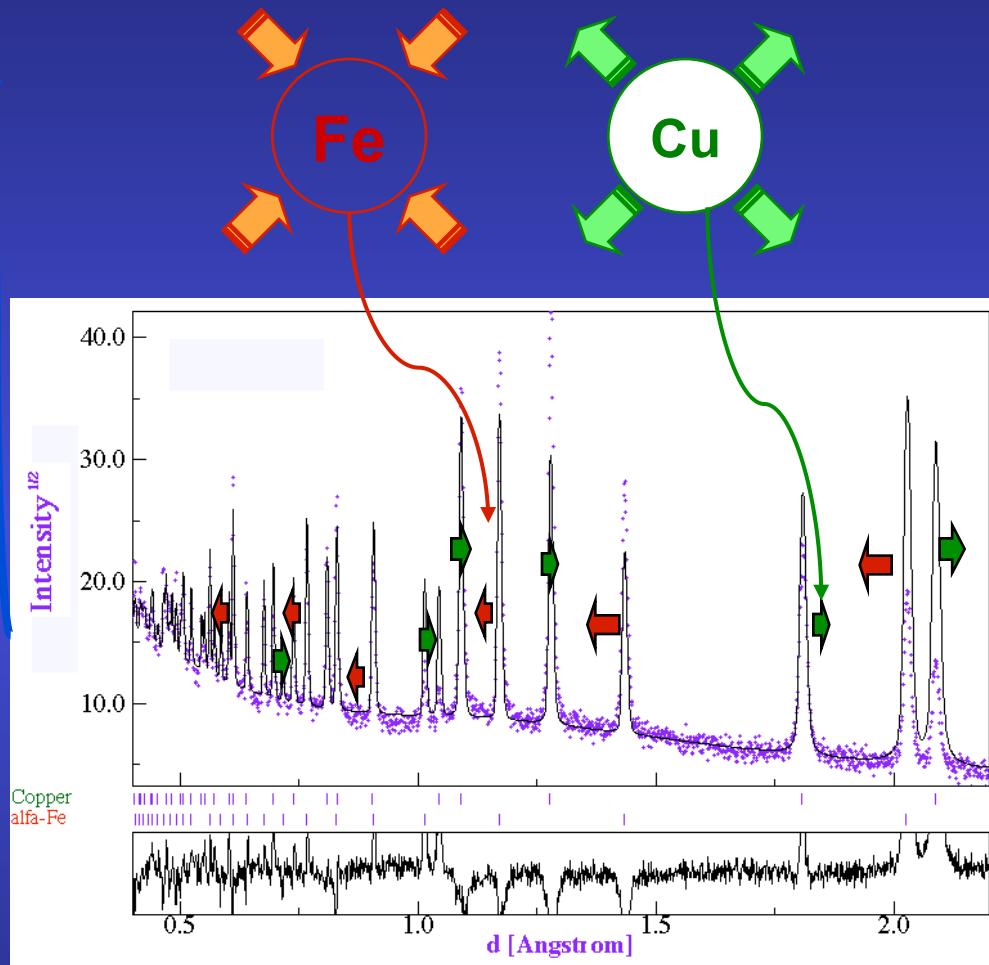
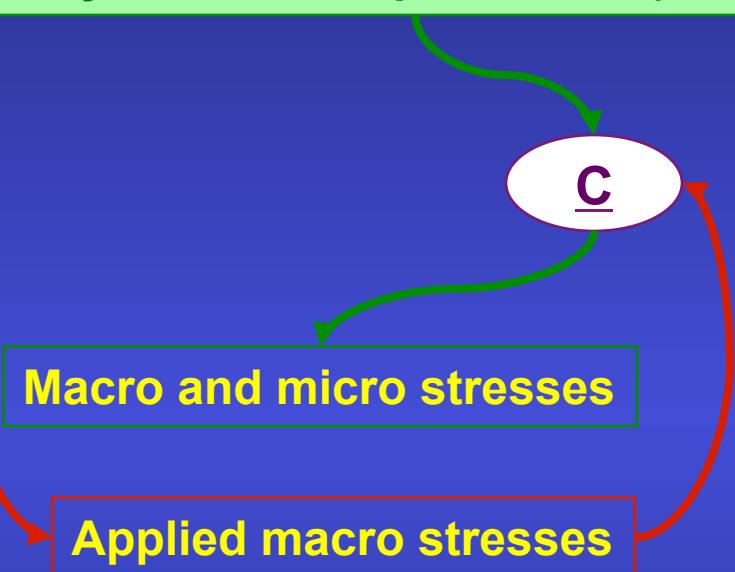
- Measured with pole figures
- needs the mean peak position

Isotropic samples: triaxial, biaxial, uniaxial stress states

Textured samples: Reuss, Voigt, Hill, Bulk geometric mean approaches

Residual Stresses and Rietveld

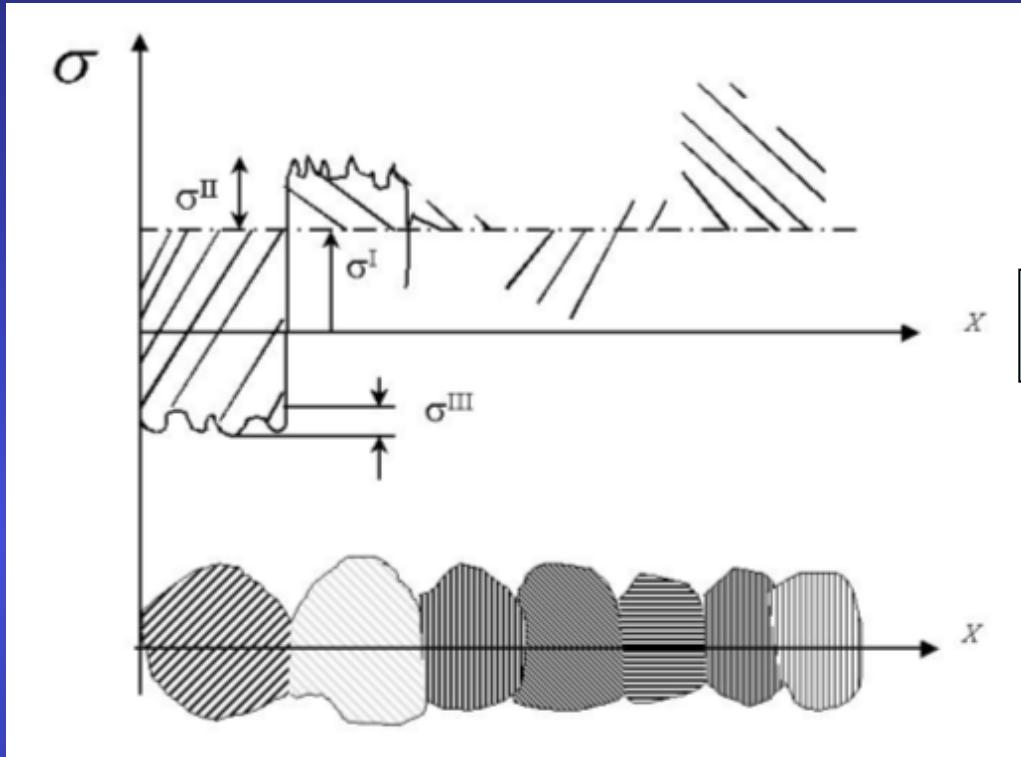
- Macro elastic strain tensor (I kind)
- Crystal anisotropic strains (II kind)



Isotropic samples: triaxial, biaxial, uniaxial stress states

Textured samples: Reuss, Voigt, Hill, Bulk geometric mean approaches

Strain-Stress



$$\boldsymbol{\varepsilon}(\mathbf{X}) = \boldsymbol{\varepsilon}^I + \boldsymbol{\varepsilon}^{II}(\mathbf{X}) + \boldsymbol{\varepsilon}^{III}(\mathbf{X})$$

$$\langle S \rangle_{geo}^{-1} = \exp \left[- \sum_{m=1}^N v_m \ln S_m \right] = \exp \left[\sum_{m=1}^N v_m \ln S_m^{-1} \right] = \langle S^{-1} \rangle_{geo} = \langle C \rangle_{geo}$$

or

$$\langle S \rangle_{geo}^{-1} = \left[\prod_{m=1}^N S_m^{v_m} \right]^{-1} = \prod_{m=1}^N S_m^{-v_m} = \prod_{m=1}^N (S_m^{-1})^{v_m} = \langle S^{-1} \rangle_{geo} = \langle C \rangle_{geo}$$

Layered systems

Problem 3

Layer, Rietveld and QTA: correlations: $f(g)$, thicknesses and structure

$f(g)$:

- Pole figures need corrections for abs-vol
- Rietveld also to correct intensities

layers:

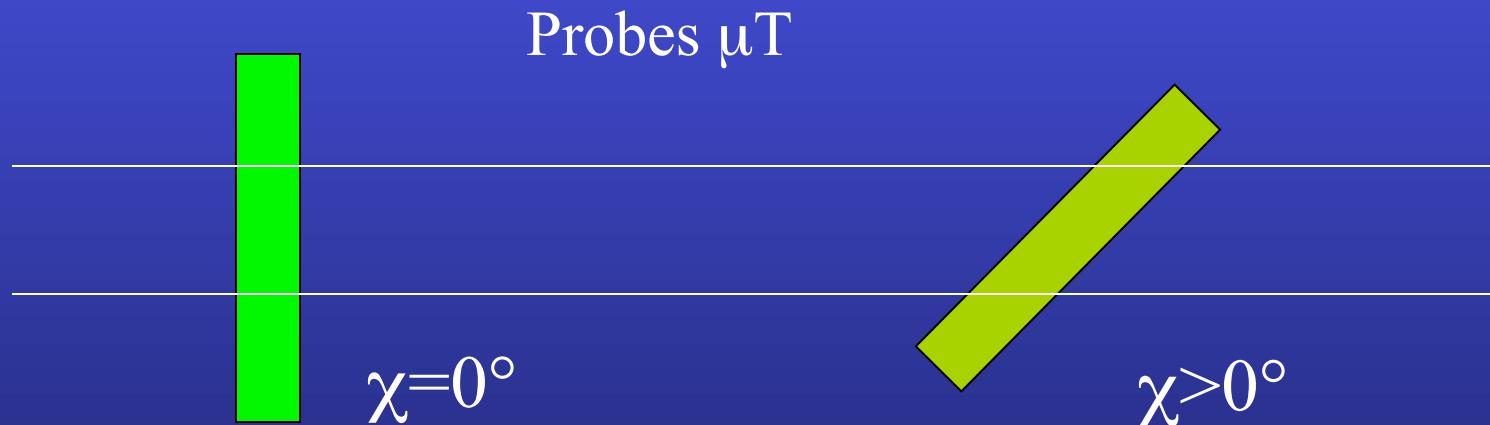
- unknown sample true absorption coefficient μ
- unknown effective thickness (porosity)

Layering

Asymmetric Bragg-Brentano

$$C_{\chi}^{\text{top film}} = g_1 \left(1 - \exp(-\mu T g_2 / \cos \chi) \right) / \left(1 - \exp(-2\mu T / \sin \omega \cos \chi) \right)$$

$$C_{\chi}^{\text{cov. layer}} = C_{\chi}^{\text{top film}} \left(\exp \left(-g_2 \sum \mu_i' T_i' / \cos \chi \right) \right) / \left(\exp \left(-2 \sum \mu_i' T_i' / \sin \omega \cos \chi \right) \right)$$



Phase and Texture

Problem 4

Phase and QTA: correlations: $f(g)$, S_Φ

$f(g)$:

- angular relationships
- plays on individual spectra
- essential to operate on textured sample

S_Φ :

- plays on overall scale factor (sum diagram)

Phase analysis

- Volume fraction

$$V_{\Phi} = \frac{S_{\Phi} V_{uc\Phi}^2}{\sum_{\Phi} (S_{\Phi} V_{uc\Phi}^2)_{\Phi}}$$

- Weight fraction

$$m_{\Phi} = \frac{S_{\Phi} Z_{\Phi} M_{\Phi} V_{uc\Phi}^2}{\sum_{\Phi} (S_{\Phi} Z_{\Phi} M_{\Phi} V_{uc\Phi}^2)_{\Phi}}$$

Z = number of formula units

M = mass of the formula unit

V = cell volume

How it works

Le Bail extraction

$$T_{hkl}^k = T_{hkl}^{k-1} \frac{\sum_i I_i^{\text{exp}} S_{hkl}^i}{\sum_i I_i^{\text{calc}} S_{hkl}^i}$$

- Starts with nominal intensities (T_{hkl})
- Computes the full pattern (I^{calc})
- Uses the formula to compute next T_{hkl}
- Cycle the last two steps until convergence
- In Maud, options:
 - Only few cycles for texture (3-5) necessary
 - The range for the weighting of the profile can be reduced
 - Background subtracted or not

Structure and Residual Stresses (shift peaks with y)

Problem 5

Stress and cell parameters: correlations: peak positions and C_{ijkl}

Cell parameters:

- Measured at high angles
- Bragg law evolution

strains:

- Measured precisely at high angles
- stiffness-based variation, also with Ψ

Shapes, microstrains, defaults, distributions

Problem 6

Shapes and stress-texture-structure: correlations ?

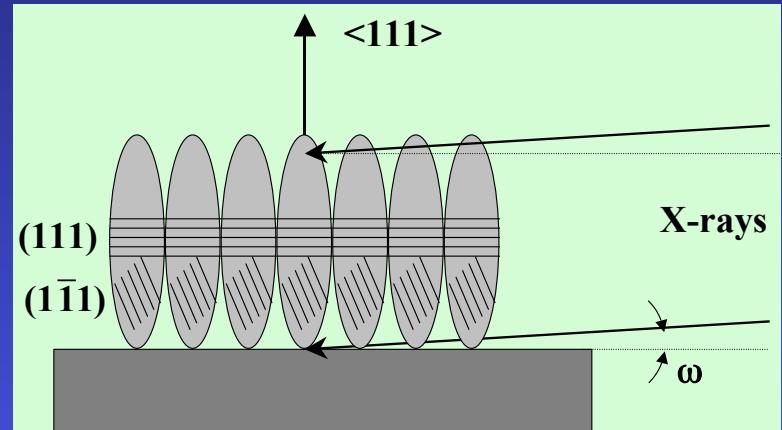
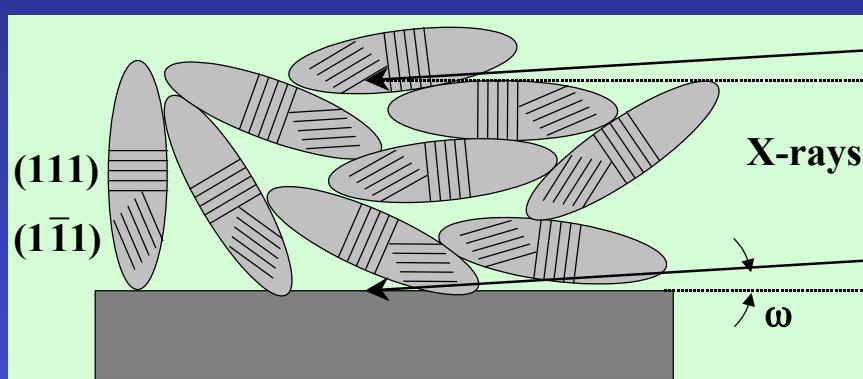
Shapes:

- line broadening problem
- average positions modified
- if anisotropic: modification changes with y

Stress-texture-structure:

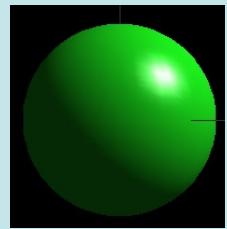
- need “true” peak positions and intensities
- need deconvoluted signals

Anisotropic sizes and microstrains



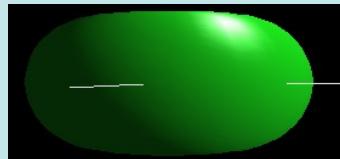
- Texture helps the "real" mean shape determination
- Determination by peak deconvolution + Popa formalism

$$\begin{aligned} \langle R_h \rangle &= R_0 + R_1 P_2^0(x) + R_2 P_2^1(x) \cos \varphi + R_3 P_2^1(x) \sin \varphi + R_4 P_2^2(x) \cos 2\varphi + R_5 P_2^2(x) \sin 2\varphi + \dots \\ \langle \varepsilon_h^2 \rangle E_h^4 &= E_1 h^4 + E_2 k^4 + E_3 \ell^4 + 2E_4 h^2 k^2 + 2E_5 \ell^2 k^2 + 2E_6 h^2 \ell^2 + 4E_7 h^3 k + 4E_8 h^3 \ell + 4E_9 k^3 h + 4E_{10} k^3 \ell + 4E_{11} \ell^3 h + 4E_{12} \ell^3 k + 4E_{13} h^2 k \ell + 4E_{14} k^2 h \ell + 4E_{15} \ell^2 k h \end{aligned}$$

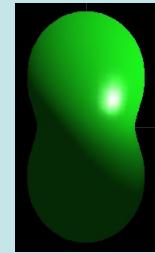


$\bar{1}$

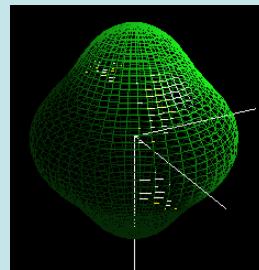
R_0



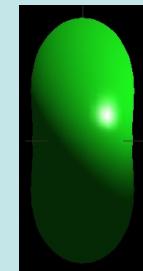
$R_0, R_1 < 0$



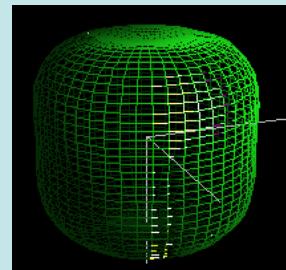
$R_0, R_1 > 0$



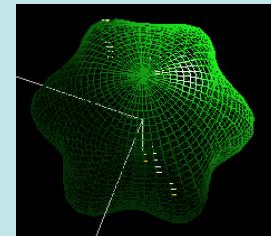
$R_0, R_6 > 0$



$R_0,$
 R_2 and $R_6 > 0$

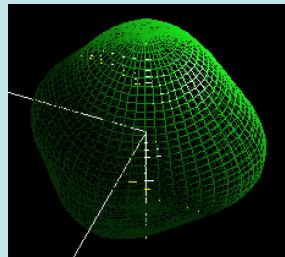


$R_0, R_6 < 0$

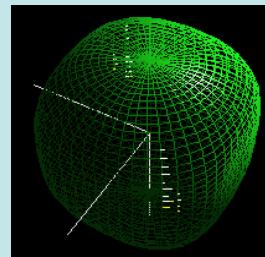


$6/m$

$R_0, R_4 > 0$



$R_0, R_1 > 0$

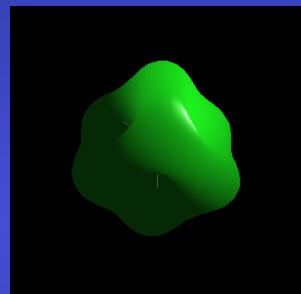


$m3m$

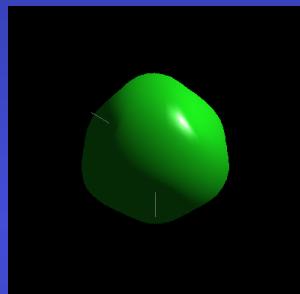
$R_0, R_1 < 0$

Gold thin films

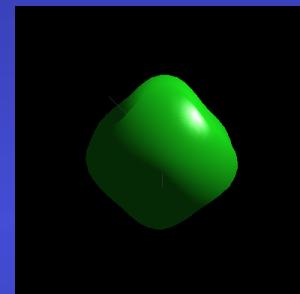
Crystallite size (Å) along	Film thickness					
	10nm	15nm	20nm	25nm	35nm	40nm
[111]	176	153	725	254	343	379
[200]	64	103	457	173	321	386
[202]	148	140	658	234	337	381



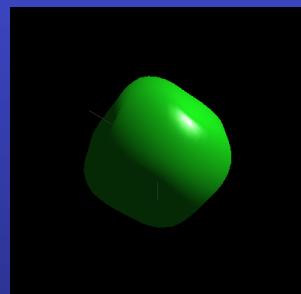
10 nm



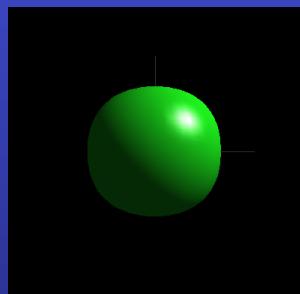
15 nm



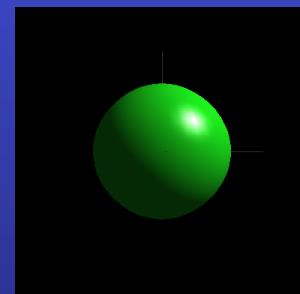
20 nm



25 nm

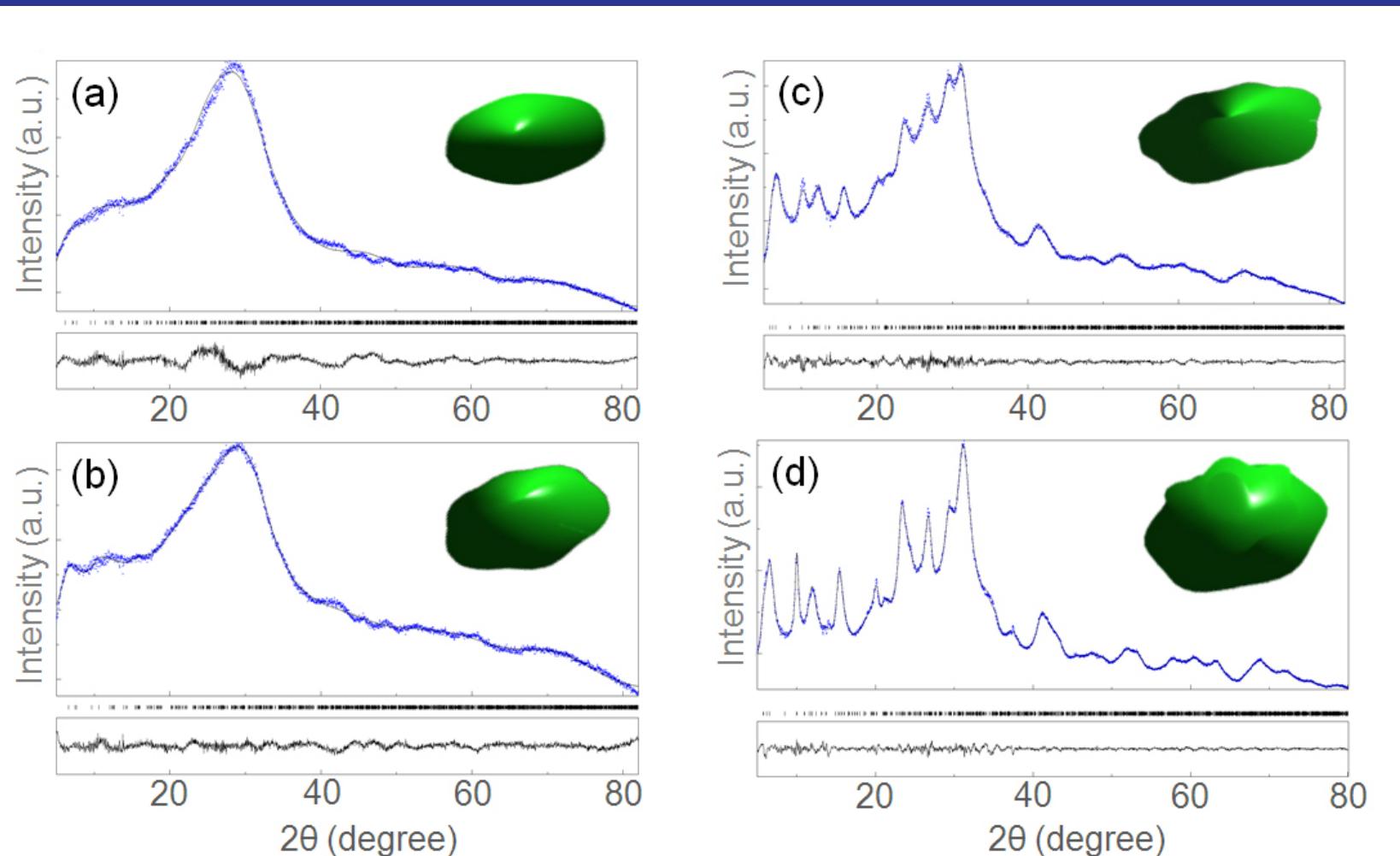


35 nm

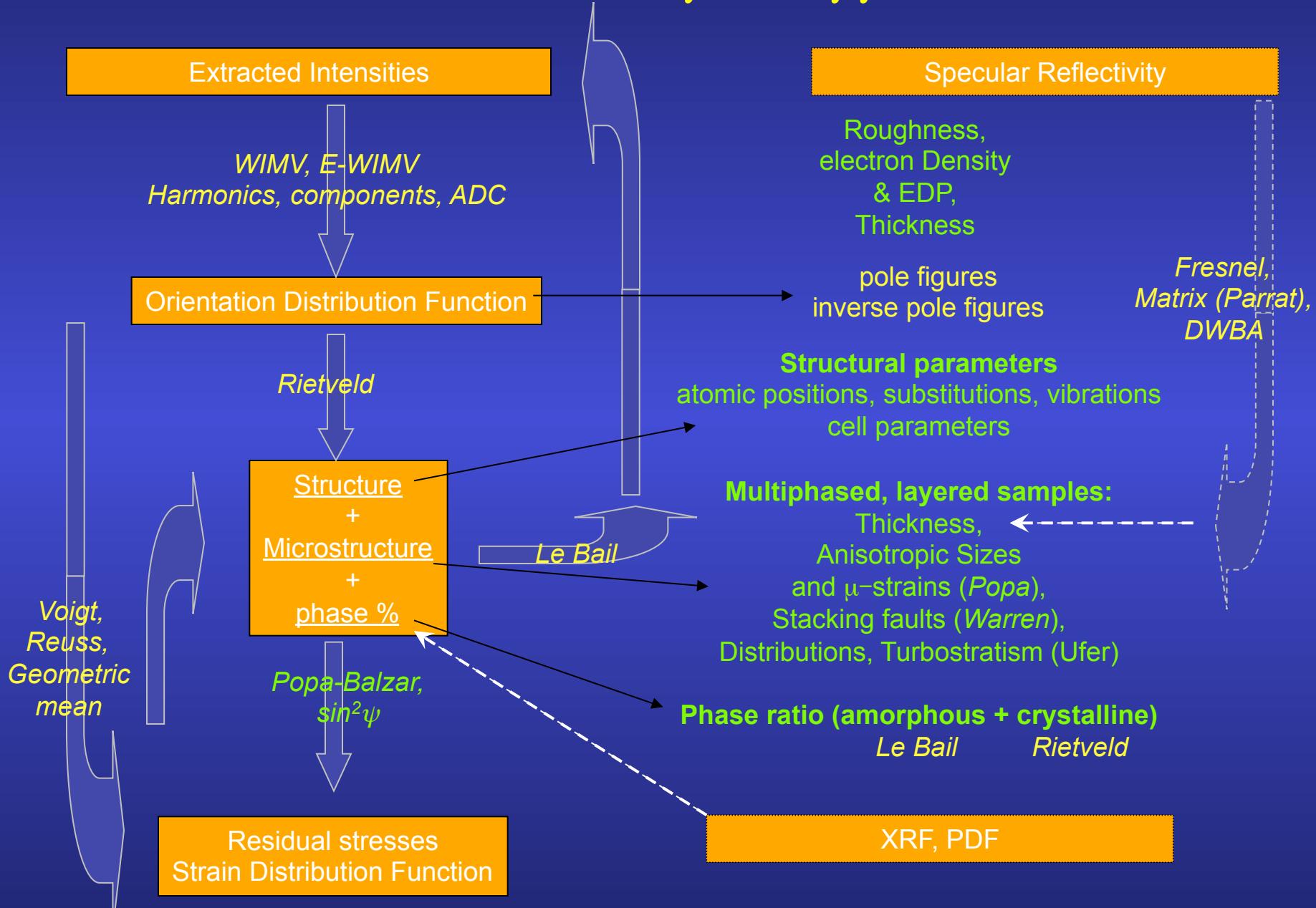


40 nm

EMT nanocrystalline zeolite



Combined Analysis approach



Grinding to powderise another problem !

Grinding: removes angular relationship, adds correlations

Texture:

- not measured
 - removed ? hope to get a perfect powder
- Strains, defaults, anisotropy ... :
- some removed, some added

Same sample ?

Rare samples ?

Minimum experimental requirements

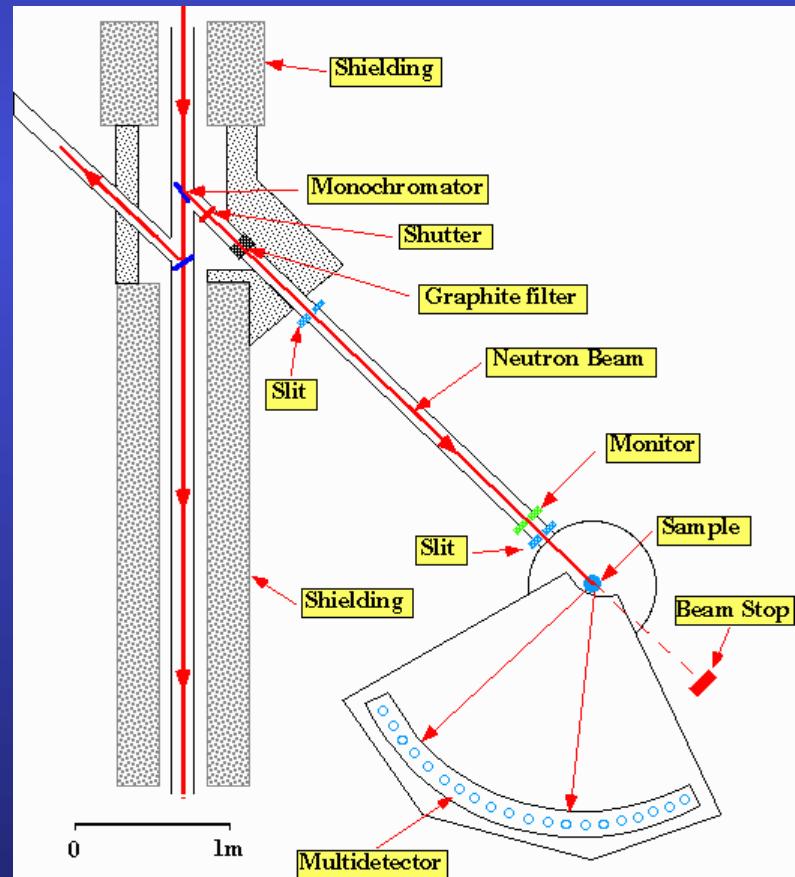
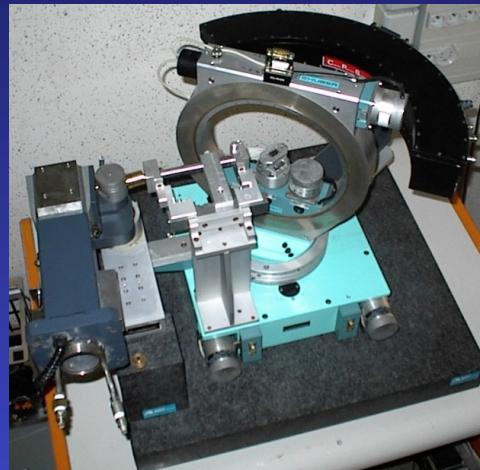
1D or 2D Detector + 4-circle diffractometer
(X-rays and neutrons)
CRISMAT, ILL

+

~1000 experiments (2θ diagrams)
in as many sample orientations

+

Instrument calibration
(peaks widths and shapes,
misalignments, defocusing ...)



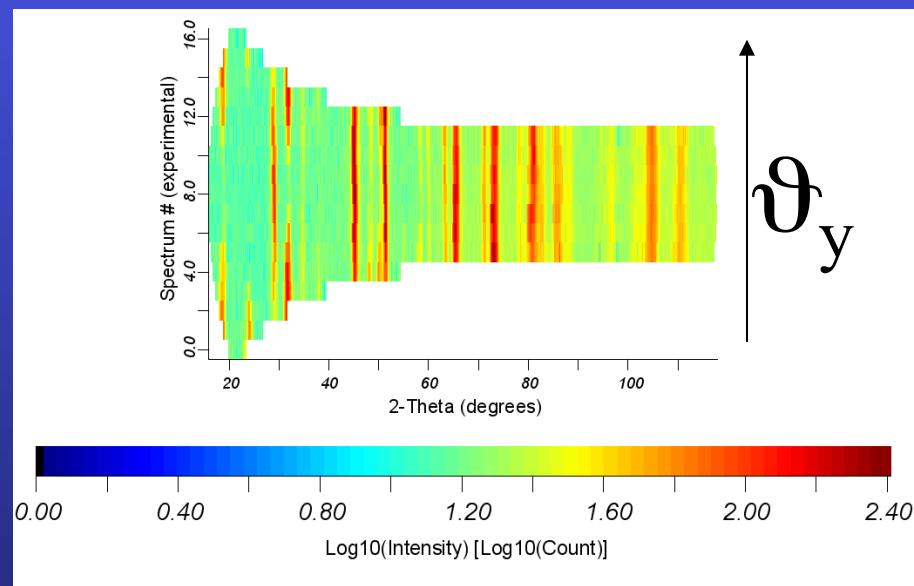
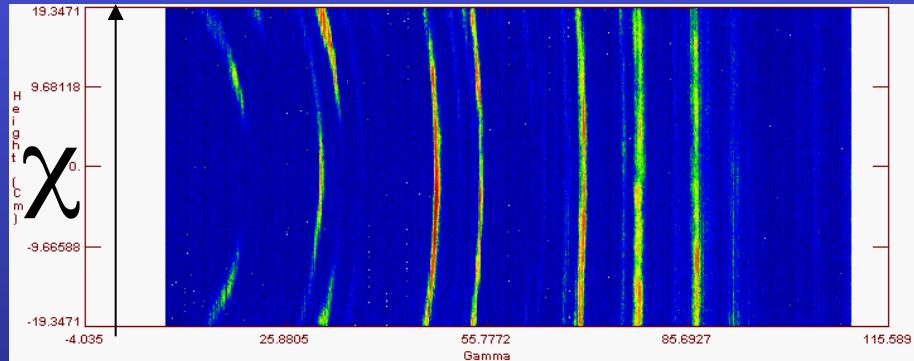
2D Curved Area Position Sensitive Detector



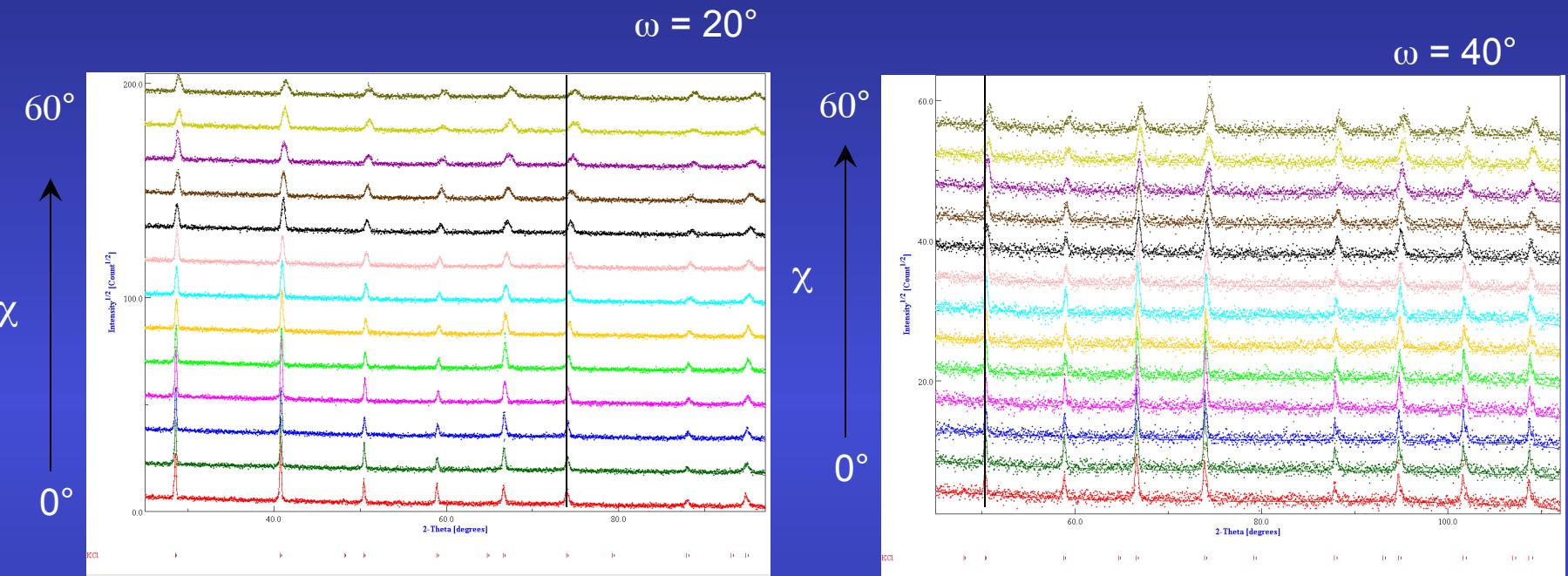
D19 - ILL

+

~100 experiments (2D Debye-Scherrer diagrams)
in as many sample orientations



Calibration



KCl, LaB₆ ...



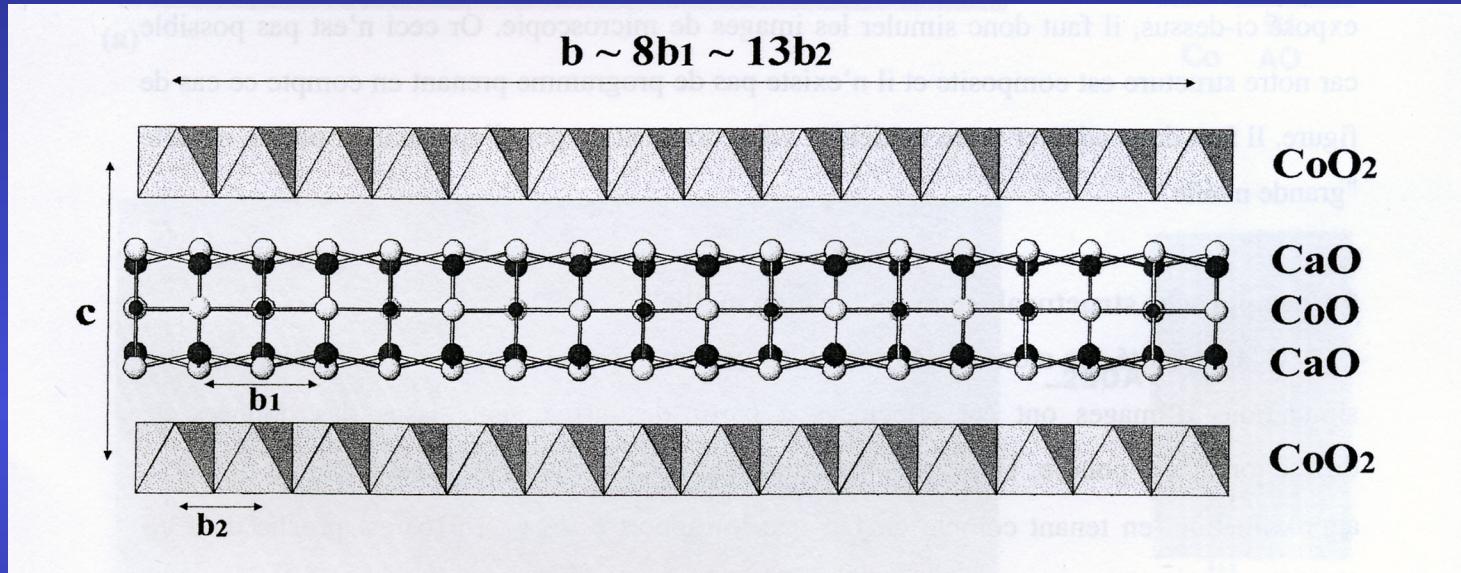
FWHM ($\omega, \chi, 2\theta, \eta \dots$)
2 θ shift
gaussianity
asymmetry
misalignments ...

Minimization algorithms

- Can be fully used in the method (everywhere)
- Marquardt Least Squares (based on steepest decrease and Gauss-Newton)
 - Efficient, best with few parameters, near the solution
- Evolutionary computation (or genetic algorithm)
 - Slow, not efficient, requires a lot of resources
 - Unlimited number of parameters
 - Can start far from the solution
- Simulated annealing (the solution proceed like a random walk, but the walking step decreases as temperature decreases)
 - In between the Marquardt and evolutionary algorithms
- Simplex (generates $n+1$ starting solutions as vertices of a polygon, n number of parameters, and contract/expand the polygon around the minima)
 - Slow on convergence
 - Remains close to the solution, but explore more minima with respect to the Marquardt

Ca₃Co₄O₉ thermoelectrics

Ca₃Co₄O₉: Misfit lamellar and modulated Structure, with high thermopower

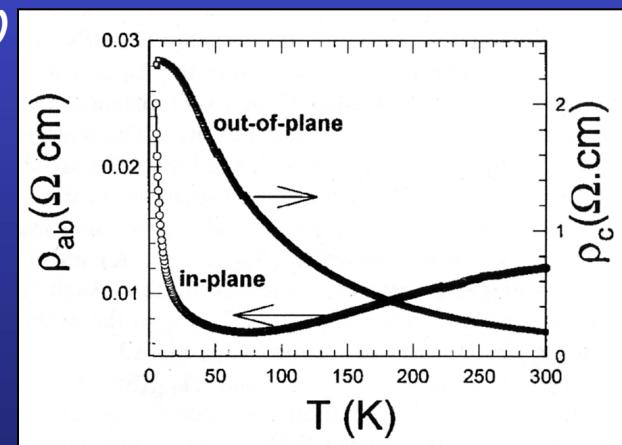


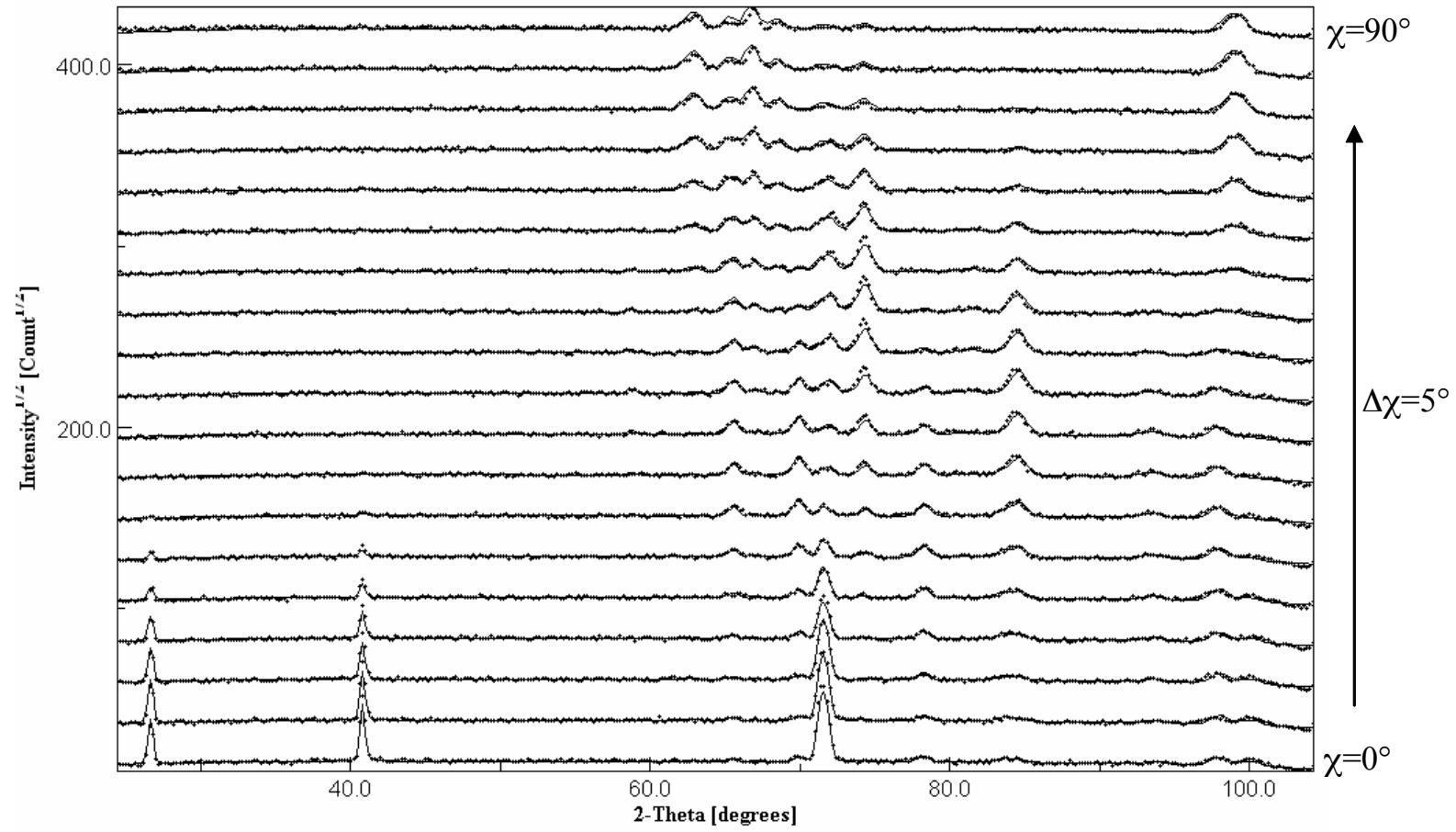
Two monoclinic sub-systems:

S1 with $a \sim 4.8\text{\AA}$, $b_1 \sim 4.5\text{\AA}$, $c \sim 10.8\text{\AA}$ et $\beta \sim 98^\circ$ (NaCl-type)

S2 with $a \sim 4.8\text{\AA}$, $b_2 \sim 2.8\text{\AA}$, $c \sim 10.8\text{\AA}$ et $\beta \sim 98^\circ$ (CdI₂-type)

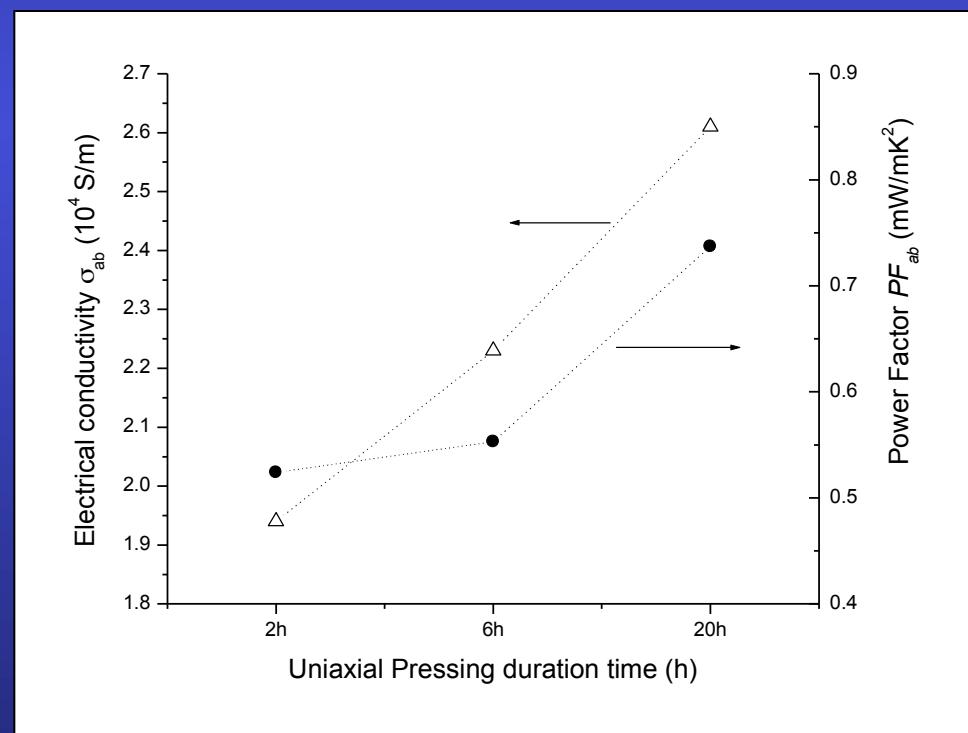
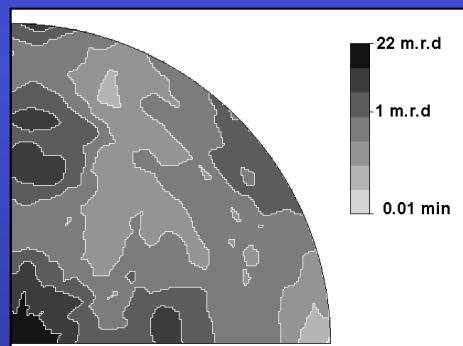
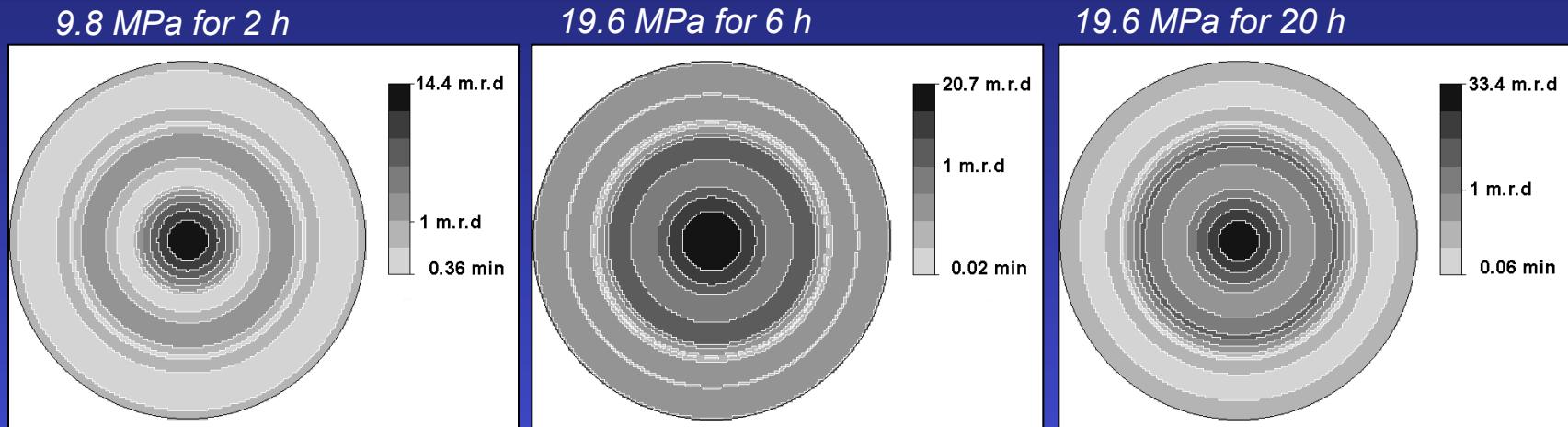
$\Gamma = \sigma_{ab}/\sigma_c \sim 10$ **Texture**





Supercell

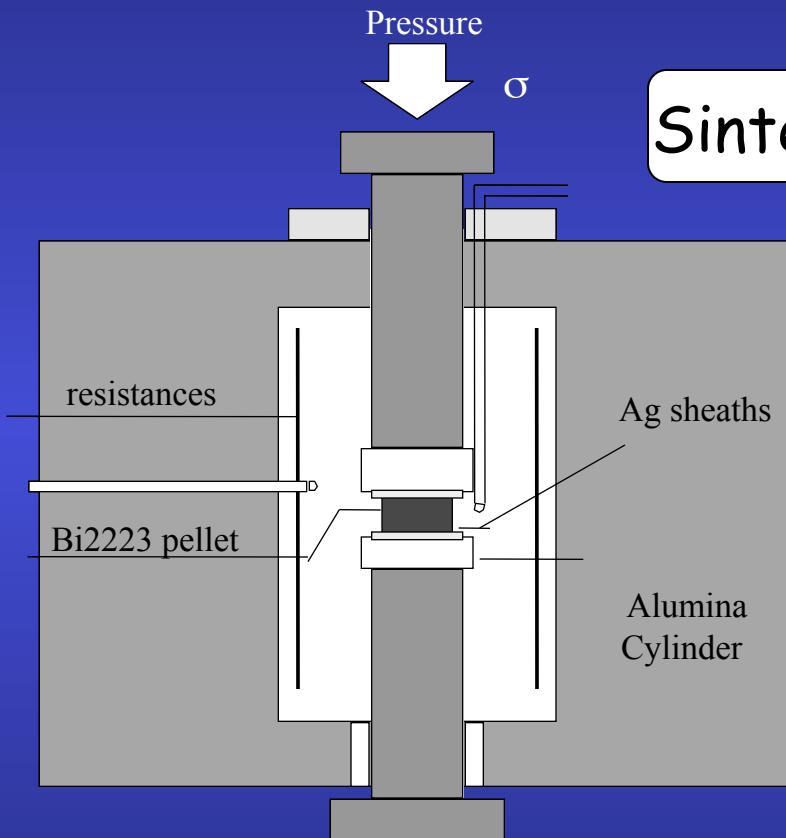
RP=19.7%, Rw=11.9%



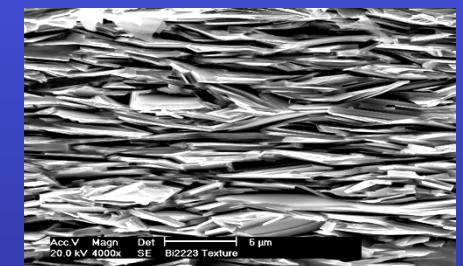
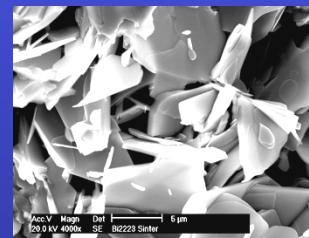
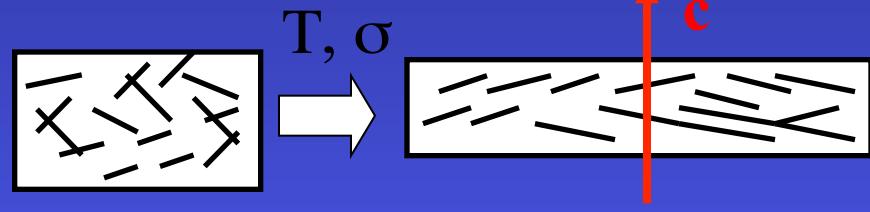
Templated Growth Method

Bi2223 compounds

E. Guilmeau, PhD

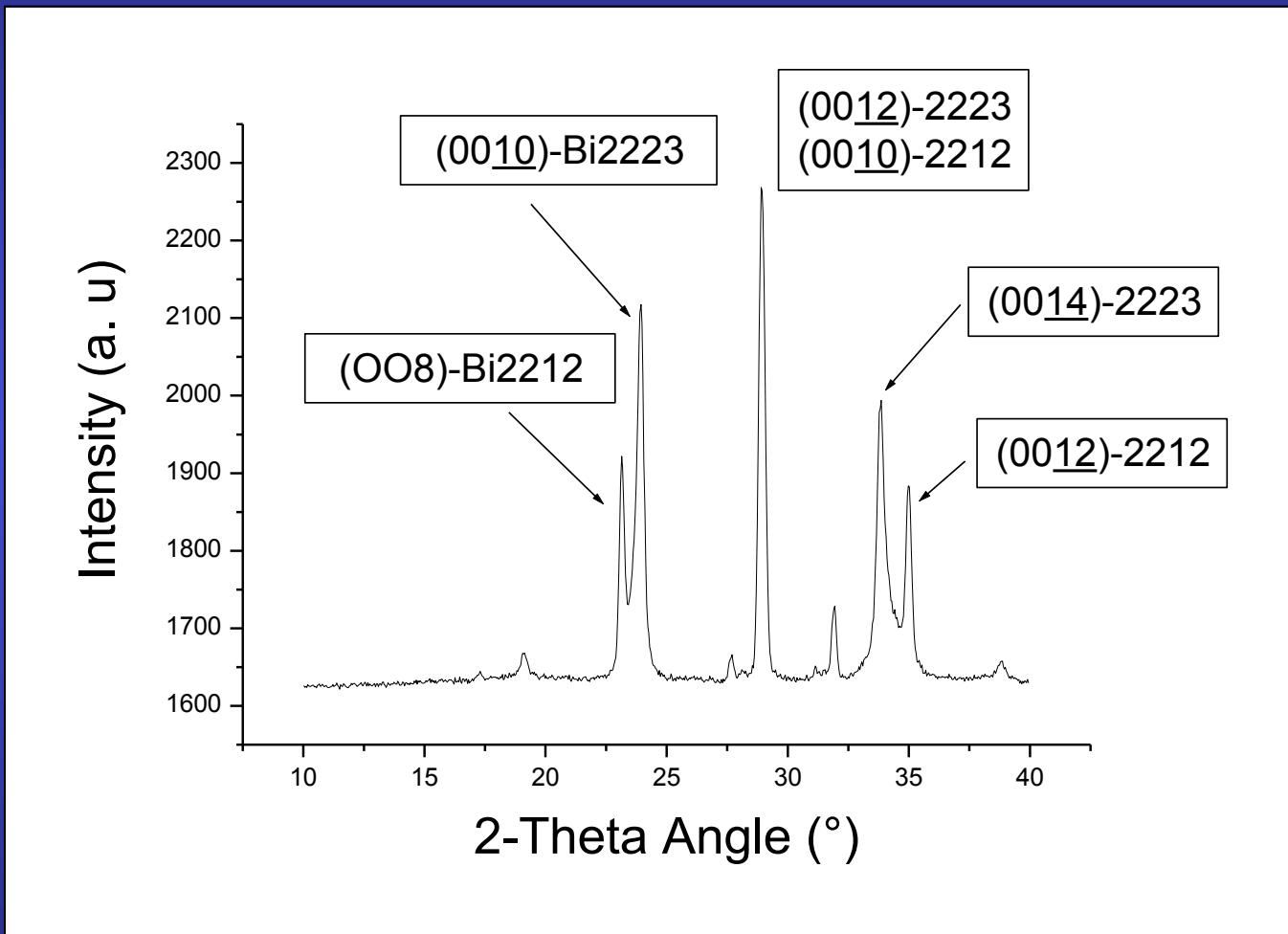


Sinter-Forging

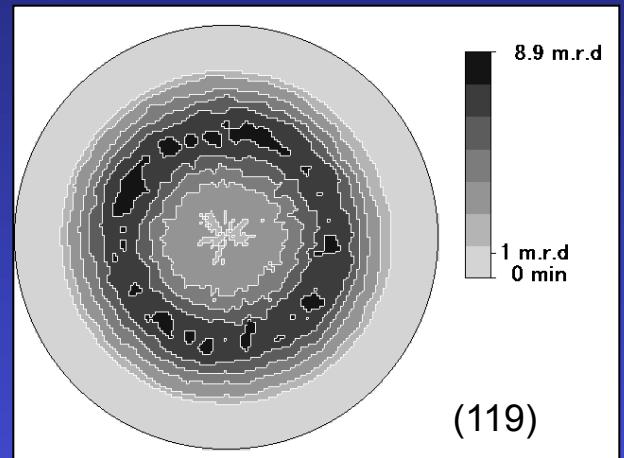
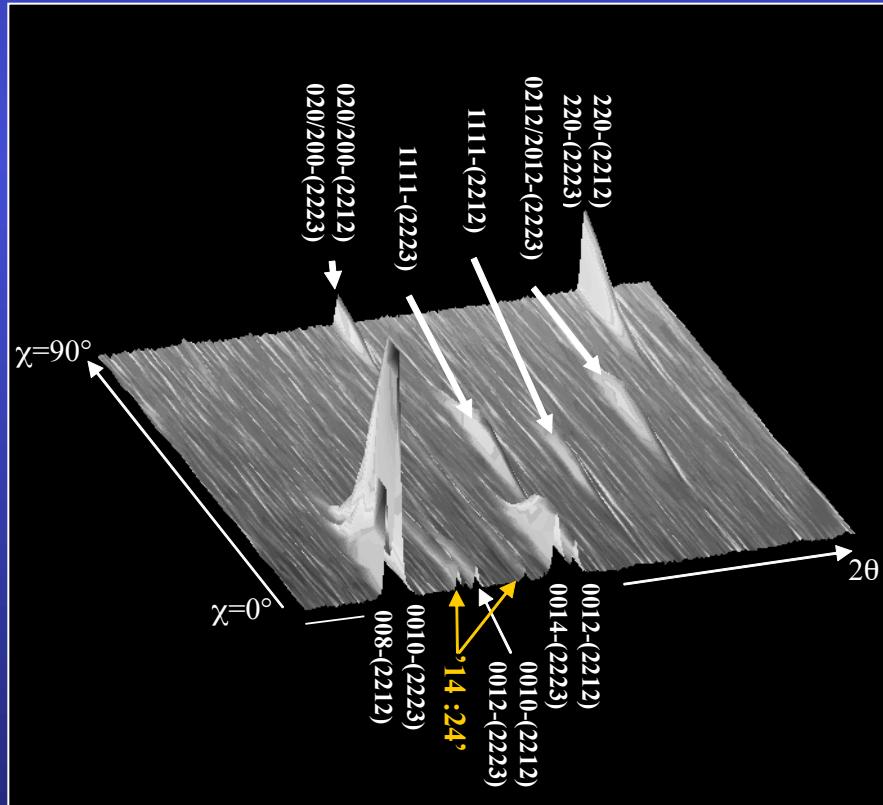


Grain alignment \Rightarrow $\nearrow J_c$

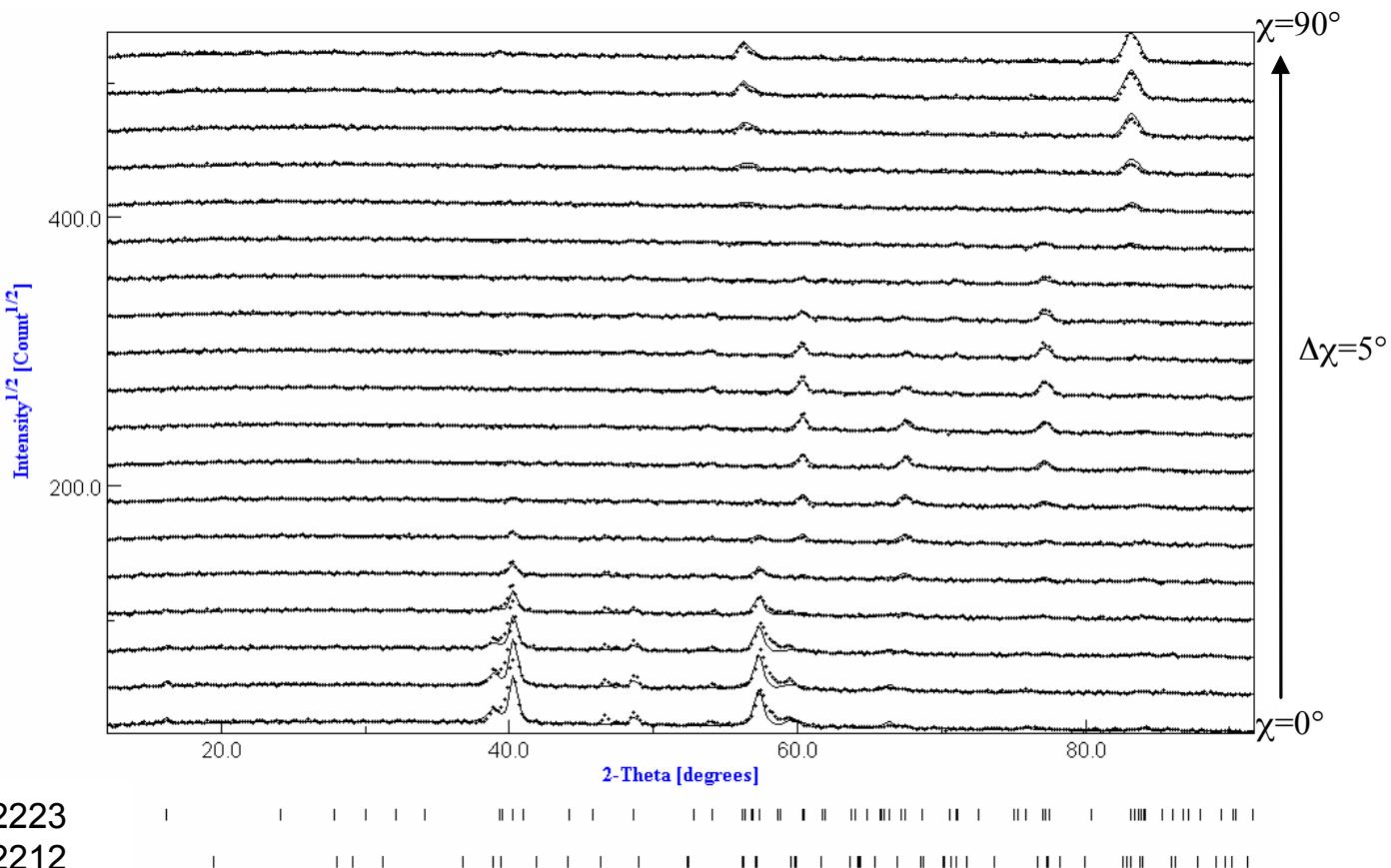
(00 ℓ) Texture



Combined Analysis



- Neutrons
- Sample: $\sim 70 \text{ mm}^3$
- 2θ patterns for $\chi=0^\circ$ to 90°
- No φ rotation (fibre texture).



Rw=9.12
RP=16.24

Effect of the sinter-forging treatment on the texture development, crystal growth, transport properties

Sinter-forging dwell time (h)	Orientation Distribution Max (m.r.d.)		% Bi2223	Cell parameters (\AA)		Crystallite size Bi2223 (nm)	R_b (%)	R_w (%)	R_{exp} (%)	R_{P0} (%)	R_{P1} (%)	J_c (A/cm^2)
	$Bi2212$	$Bi2223$		$Bi2223$	$Bi2212$							
20	21.8	20.7	59.9 \pm 1.3	a=5.419(3) b=5.391(3) c=37.168(3)	a=5.414(3) b=5.393(3) c=30.800(3)	205 \pm 7	7.56	11.1	4.55	17.74	10.56	12500
50	24.1	24.4	72.9 \pm 2.9	a=5.419(3) b=5.408(3) c=37.192(3)	a=5.416(3) b=5.396(3) c=30.806(3)	273 \pm 10	7.54	11.37	4.58	17.05	11.04	15000
100	31.5	25.2	84.4 \pm 4.6	a=5.410(3) b=5.405(3) c=37.144(3)	a=5.412(3) b=5.403(3) c=30.752(3)	303 \pm 10	5.4	8.04	3.69	13.54	9.31	19000
150	65.4	27.2	87.0 \pm 4.1	a=5.417(3) b=5.403(3) c=37.199(3)	a=5.413(3) b=5.407(3) c=30.792(3)	383 \pm 13	6.13	9.12	4.8	16.24	12.25	20000



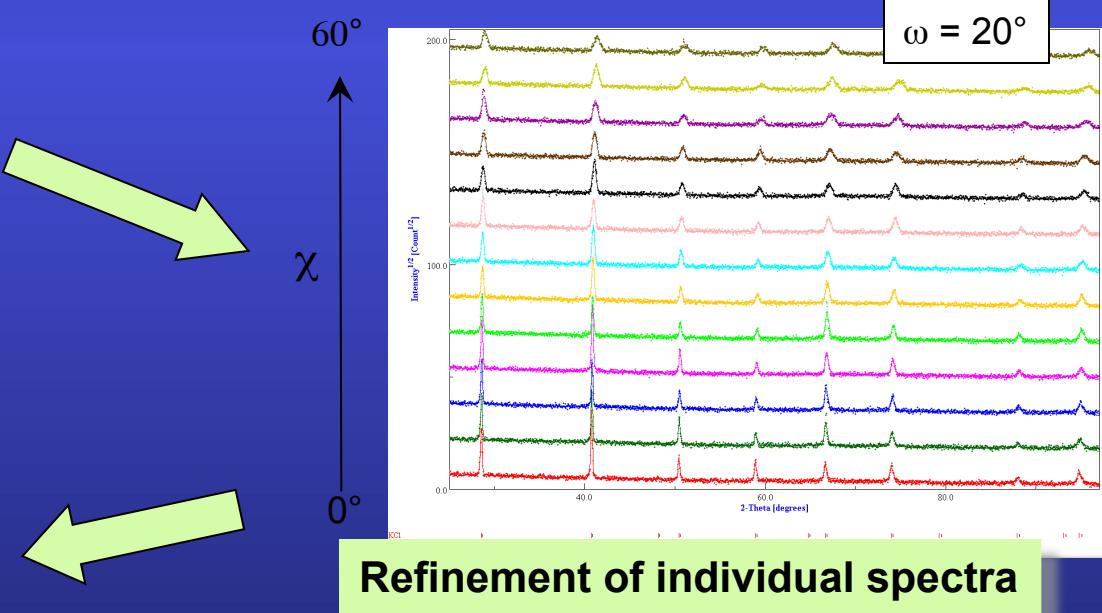
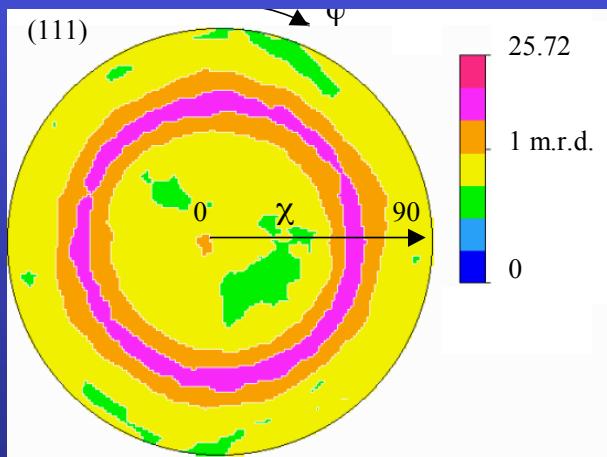
Ferroelectric PCT films

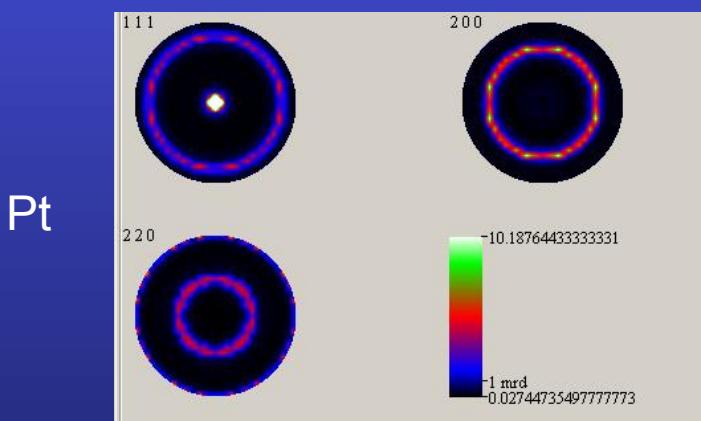
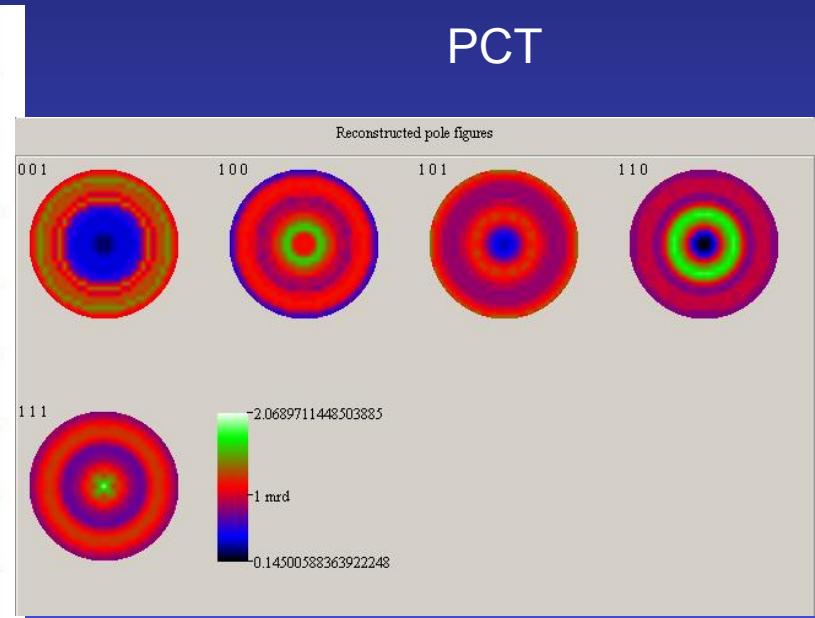
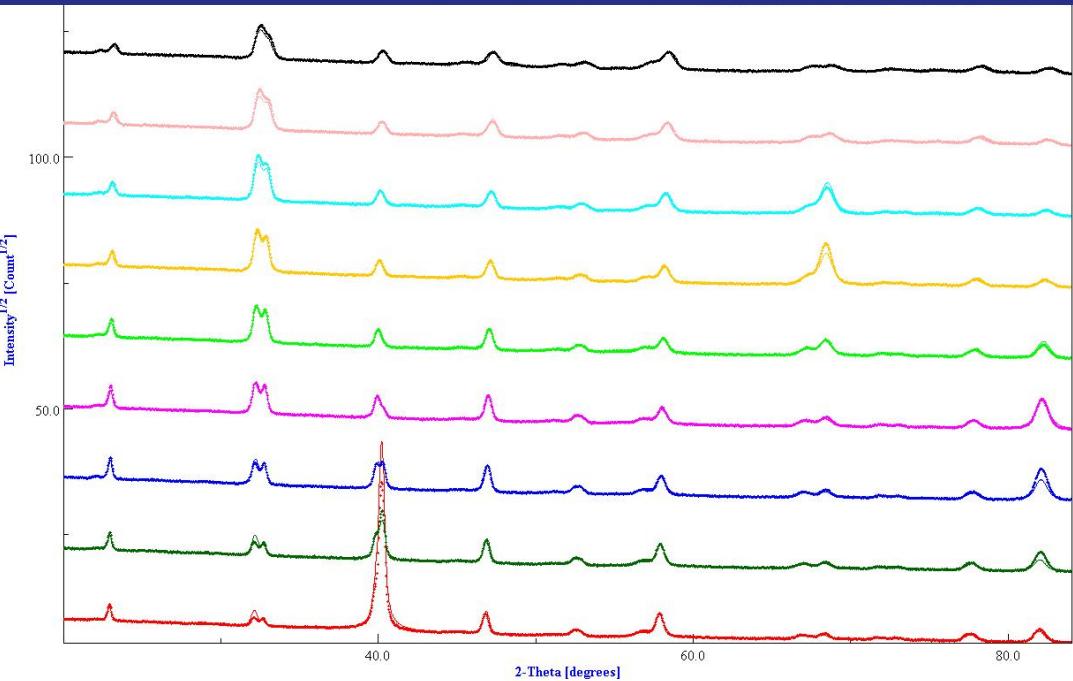
J. Ricote, Madrid

thin films:

$(\text{Ca}_{0.24}\text{Pb}_{0.76})\text{TiO}_3$ sol-gel synthesised solutions deposited by spin coating on a substrate of Pt/TiO₂/Si, with and without a treatment at 650°C for 30 min.

All films are crystallised at 700°C for 50 s by Rapid Thermal Processing (RTP; 30°C/s). A series is also recrystallised at 650°C for 1 to 3 h.



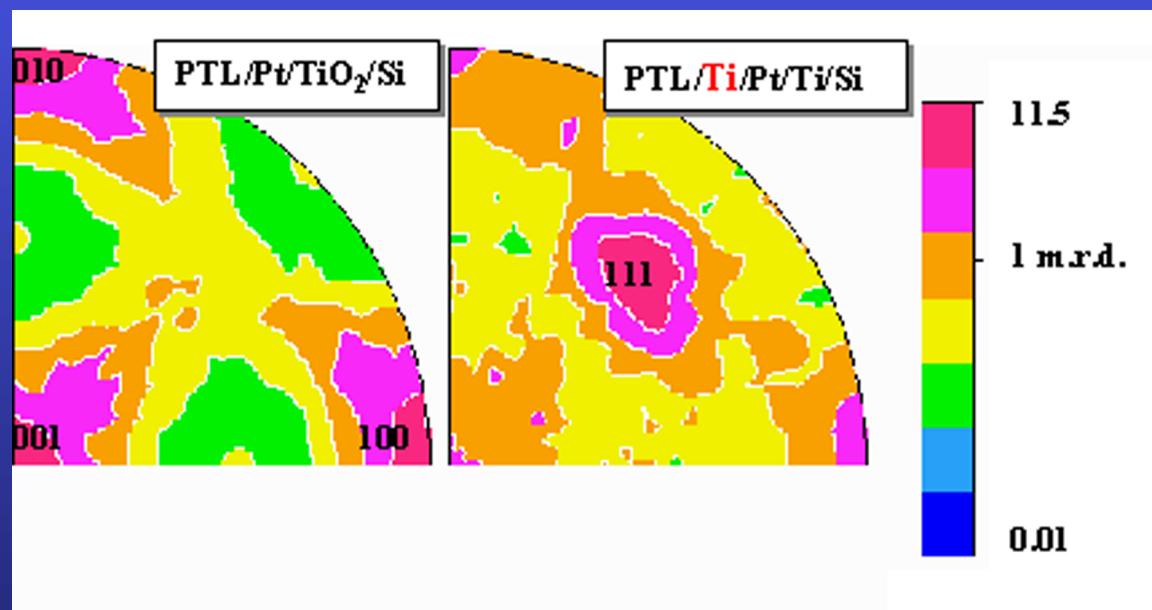


$a = 3.9108(1) \text{ \AA}$
 $T = 457(3) \text{ \AA}$
 $t_{\text{iso}} = 458(3) \text{ \AA}$
 $\varepsilon' = 0.0032(1) \text{ rms}$

$a = 3.9156(1) \text{ \AA}$
 $c = 4.0497(3) \text{ \AA}$
 $T = 2525(13) \text{ \AA}$
 $t_{\text{iso}} = 390(7) \text{ \AA}$
 $\varepsilon = 0.0067(1) \text{ rms}$

$R_w = 13\%; R_B = 12\%; R_{\text{exp}} = 22\% \text{ (Rietveld)}$
 $R_w = 5\%; R_B = 6\% \text{ (E-WIMV)}$

Atom	Occupancy	x	y	z
Pb	0.76	0.0	0.0	0.0
Ca	0.24	0.0	0.0	0.0
Ti	1.0	0.5	0.5	0.477(2)
O1	1.0	0.5	0.5	0.060(2)
O2	1.0	0.0	0.5	0.631(1)

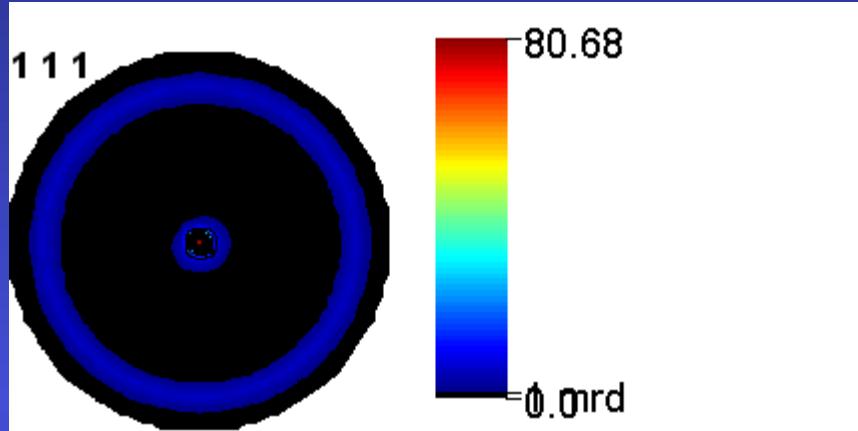


Compliance coefficients [10^{-3} GPa $^{-1}$]	PbTiO ₃ single crystal (data set A)	Film random orientation	PCT-Si <001> contrib. \approx 17%	PLT <001> contrib. \approx 49%	PCT-Mg <001> contrib. \approx 68%
S ₁₁	6.5	10.1	10.5	10.0	9.7
S ₂₂	6.5	10.0	10.5	10.0	9.7
S ₃₃	33.3	9.8	9.0	10.3	11.3
S ₄₄	14.5	13.2	12.8	12.9	13.1
S ₅₅	14.5	13.2	12.8	13.0	13.1
S ₆₆	9.6	13.4	14.0	13.5	12.7
S ₁₂	-0.35	-3.3	-3.5	-3.2	-3.0
S ₂₁	-0.35	-3.3	-3.5	-3.2	-3.0
S ₁₃	-7.1	-3.2	-3.1	-3.4	-3.6
S ₃₁	-7.1	-3.2	-3.1	-3.4	-3.6
S ₂₃	-7.1	-3.2	-3.1	-3.4	-3.6
S ₃₂	-7.1	-3.2	-3.1	-3.4	-3.6
S ₃₃ /S ₁₁	5.1	0.97	0.86	1.03	1.16
S ₁₃ /S ₁₂	20.3	0.97	0.89	1.06	1.20

Geometric mean average + biaxial stress state

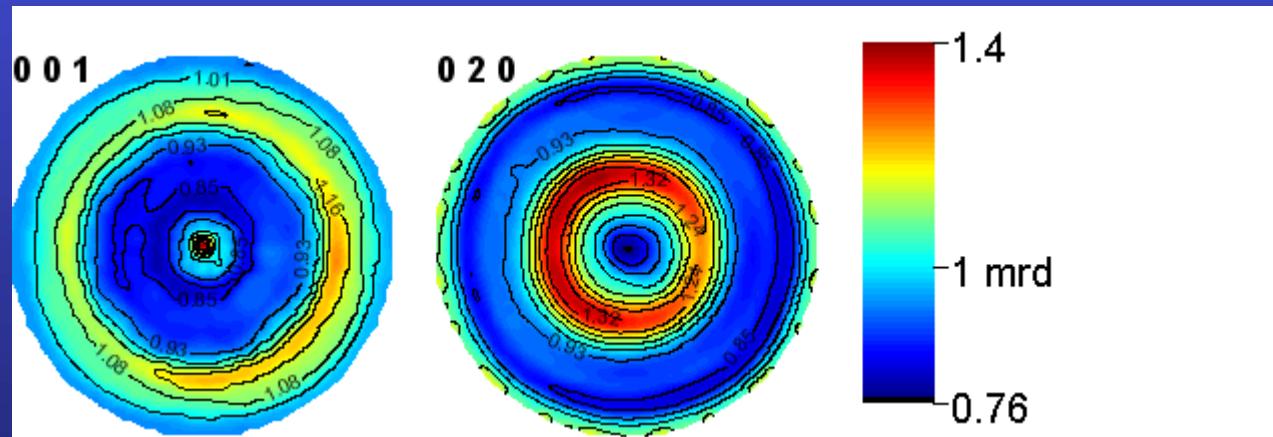
Ferroelectric PMN-PT films

J. Ricote, DMF-Madrid



Pt
 $a = 3.91172(1)$ Å
 $T = 583(5)$ Å
 $t_{iso} = 960(1)$ Å
 $\varepsilon = 0.0032(1)$ rms
 $\sigma_{11} = 0.639(1)$ GPa
 $\sigma_{22} = 0.651(1)$ GPa
 $\sigma_{12} = -0.009(1)$ GPa

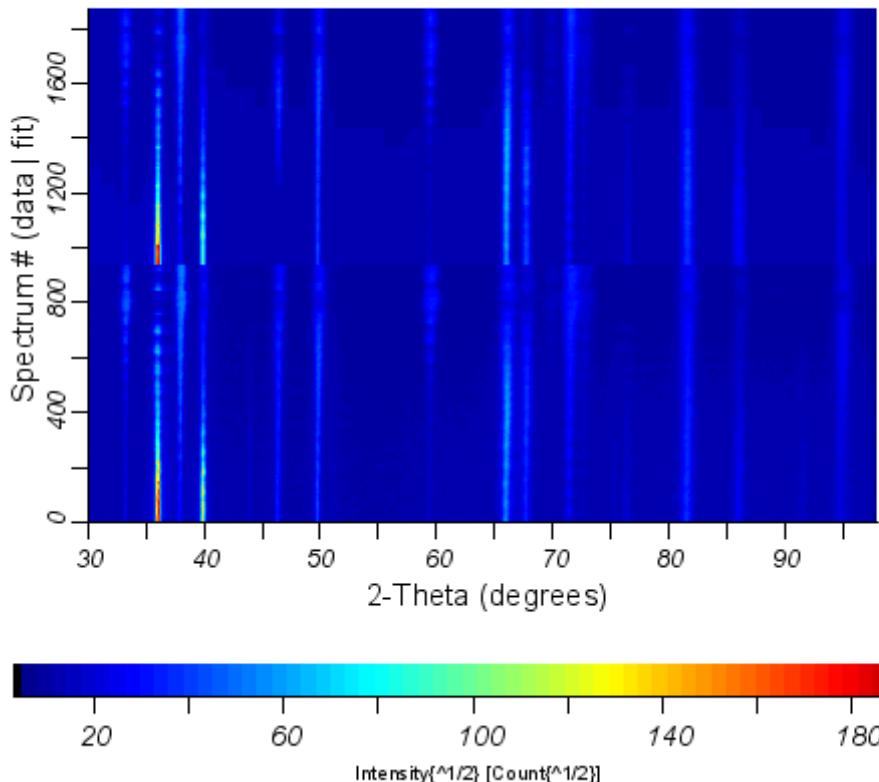
$\text{Pb}_{0.7}(\text{Mg}_{1/3}\text{Nb}_{2/3})\text{O}_3-\text{Pb}_{0.3}\text{TiO}_3/\text{TiO}_2/\text{Pt/Si-(100)}$



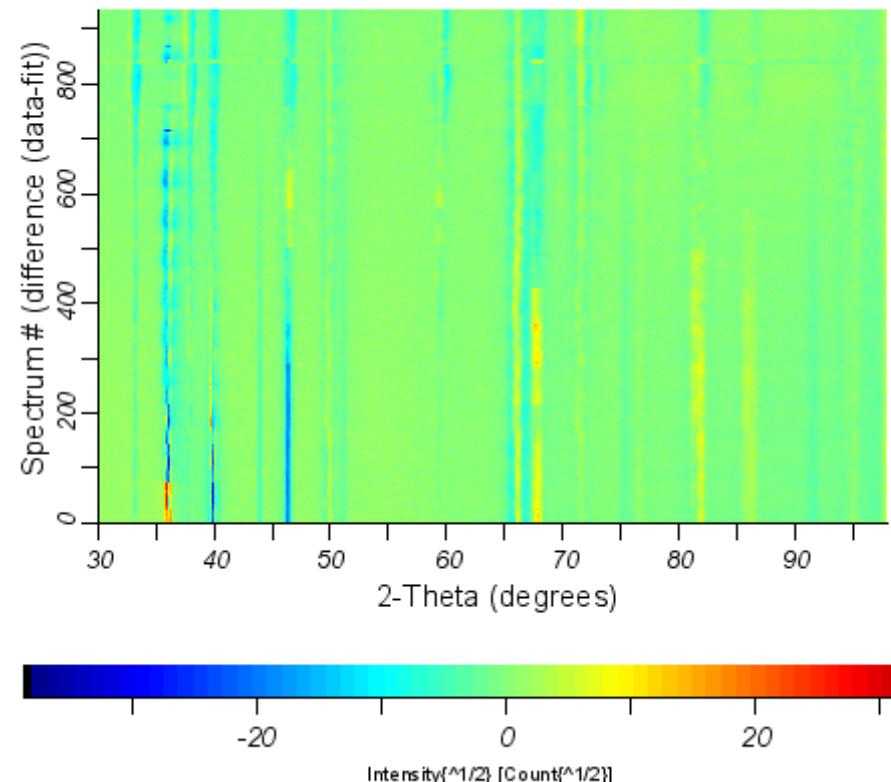
$a = 5.67858(9)$ Å
 $b = 5.69038(9)$ Å
 $c = 3.99558(4)$ Å
 $\beta = 90.392(1)$ Å
 $T = 1322(9)$ Å
 $t_{iso} = 1338(2)$ Å
 $\varepsilon = 0.0067(1)$ rms

AlN/Pt/TiO_x/Al₂O₃/Ni-Co-Cr-Al

2D Multiplot for Data 05_37P64
measured data and fit

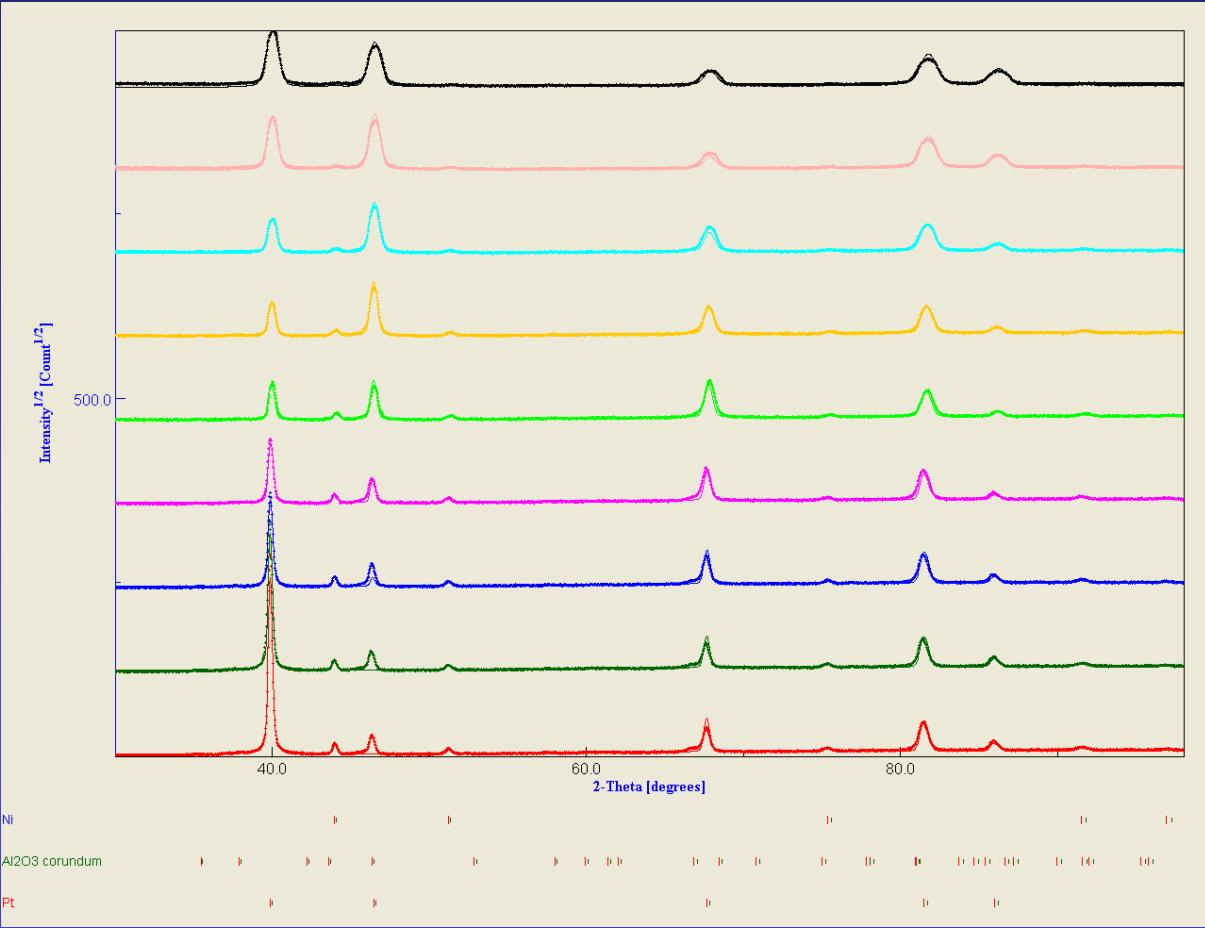


2D difference plot for Data 05_37P64
difference data - fit



Rw (%) = 24.120445
Rexp (%) = 5.8517213

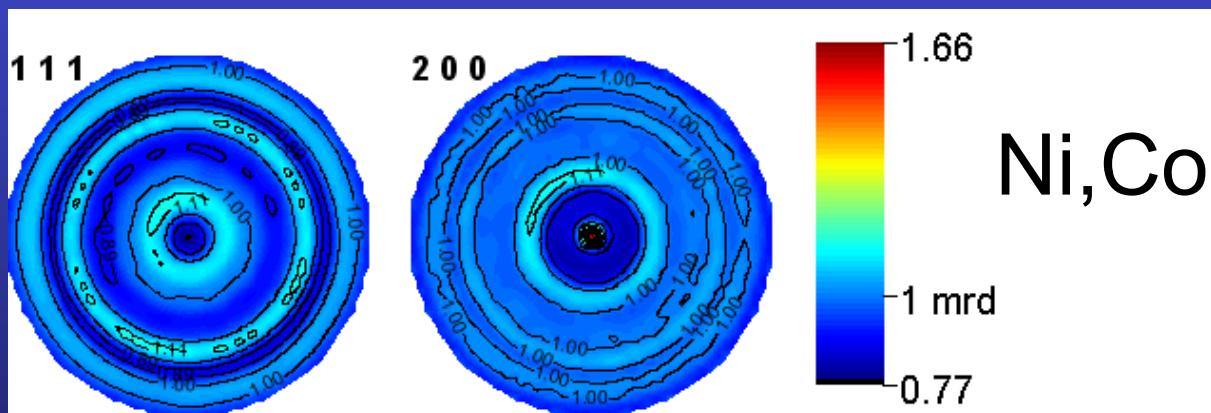
T(AlN) = 14270(3) nm
T(Pt) = 430(3) nm



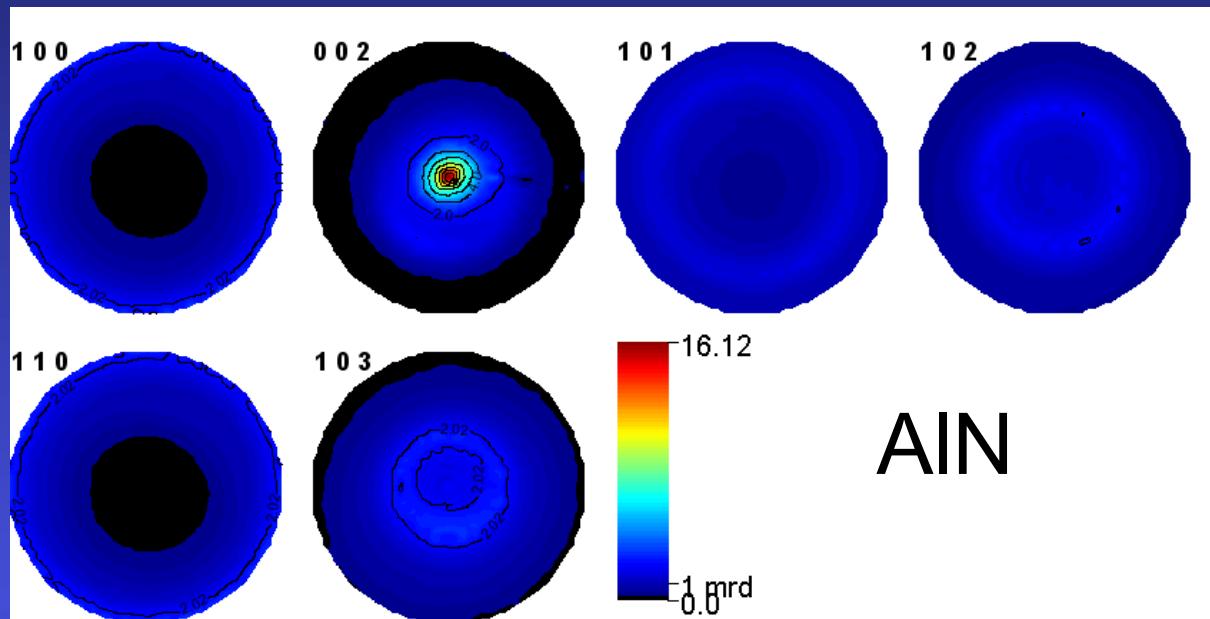
(χ, φ) randomly selected diagrams



$a = 4.7562(6) \text{ \AA}$
 $c = 12.875(3) \text{ \AA}$
 $T = 7790(31) \text{ nm}$
 $\langle t \rangle = 150(2) \text{ \AA}$
 $\langle \varepsilon \rangle = 0.008(3)$



$a = 3.569377(5) \text{ \AA}$
 $\langle t \rangle = 7600(1900) \text{ \AA}$
 $\langle \varepsilon \rangle = 0.00236(3)$
 $\sigma_{11} = -328(8) \text{ MPa}$
 $\sigma_{22} = -411(9) \text{ MPa}$



$$R_w (\%) = 4.1$$

$$a = 3.11203(1) \text{ \AA}$$

$$c = 4.98252(1) \text{ \AA}$$

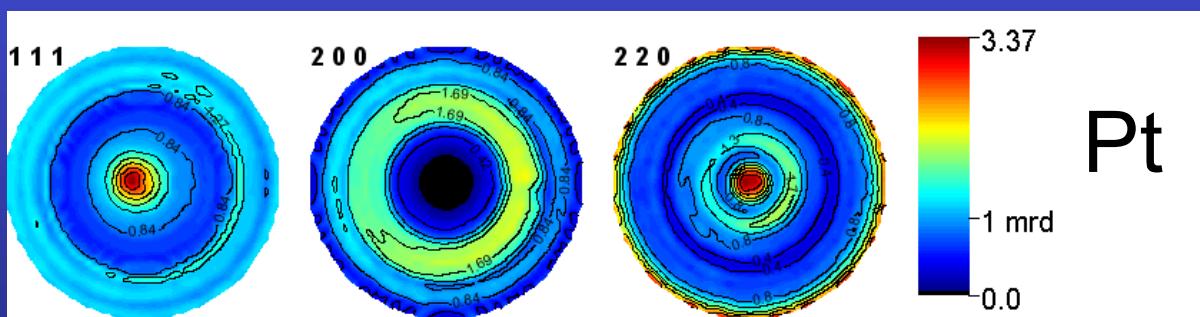
$$T = 14270(3) \text{ nm}$$

$$\langle t \rangle = 2404(8) \text{ \AA}$$

$$\langle \varepsilon \rangle = 0.001853(2)$$

$$\sigma_{11} = -1019(2) \text{ MPa}$$

$$\sigma_{22} = -845(2) \text{ MPa}$$



$$R_w (\%) = 33.3$$

$$a = 3.91198(1) \text{ \AA}$$

$$T = 1204(3) \text{ nm}$$

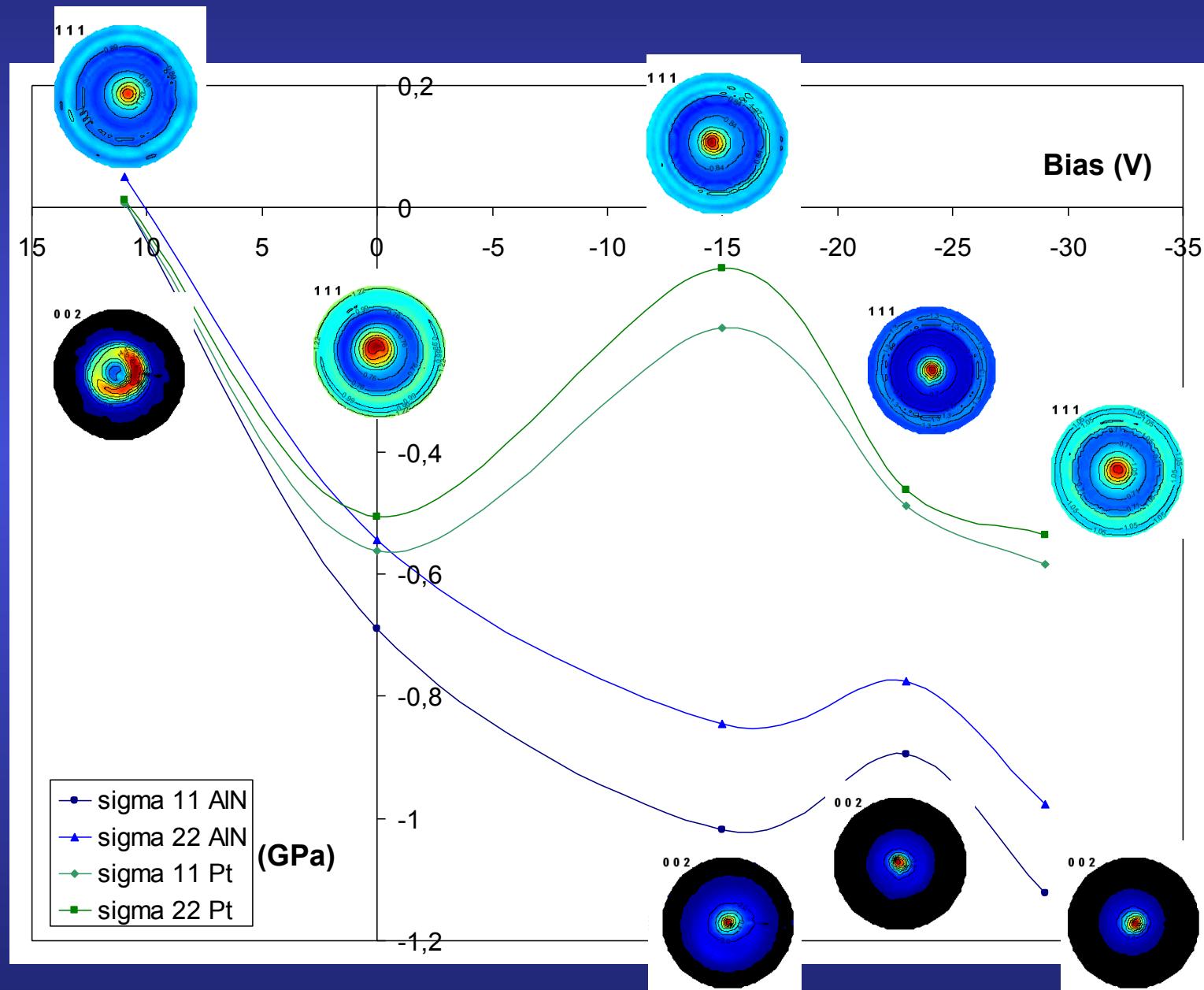
$$\langle t \rangle = 2173(10) \text{ \AA}$$

$$\langle \varepsilon \rangle = 0.002410(3)$$

$$\sigma_{11} = -196.5(8)$$

$$\sigma_{22} = -99.6(6)$$

Substrate bias vs stress-texture evolution



Si nanocrystalline thin films

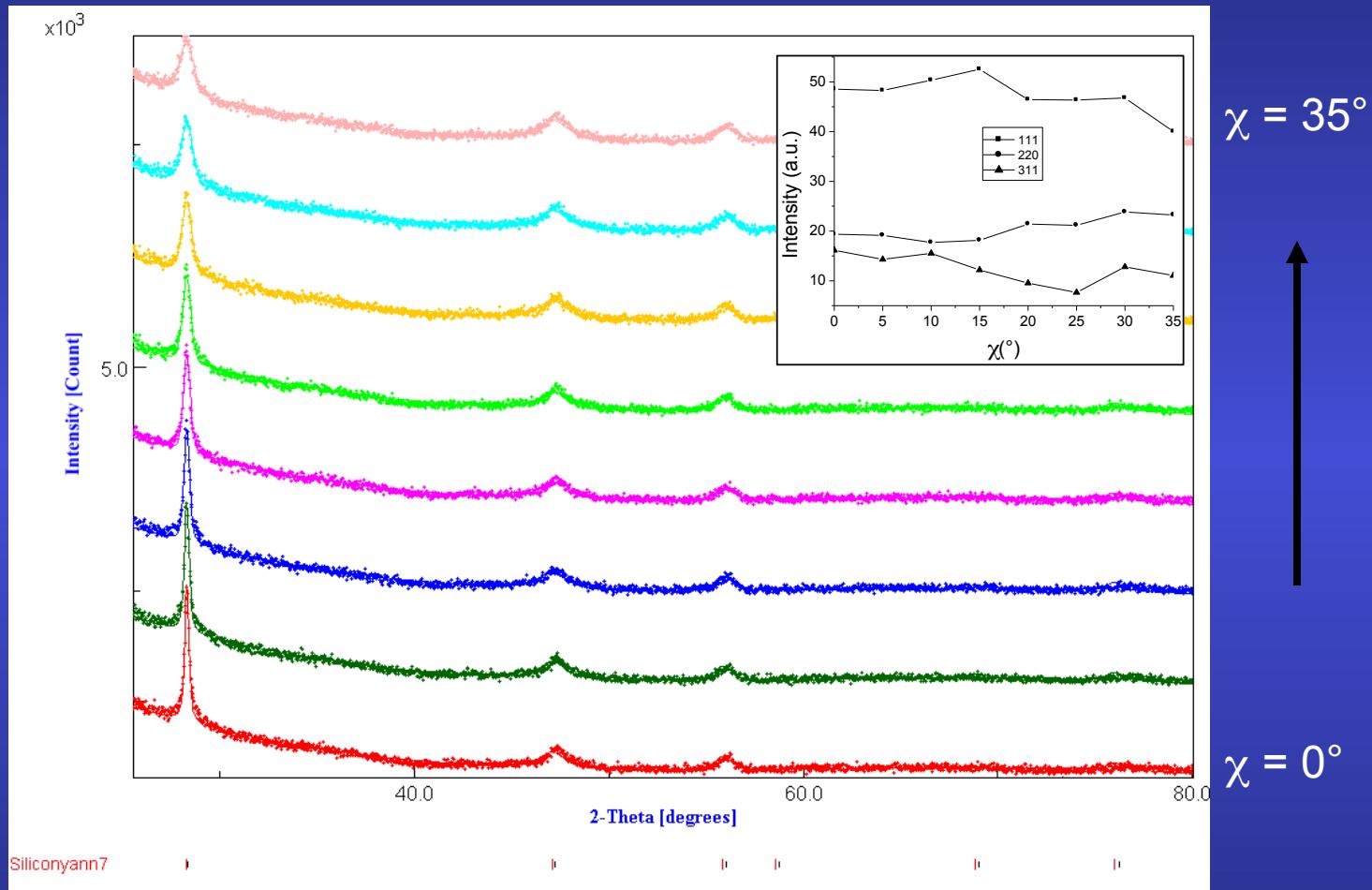
M. Morales, Caen

Silicon thin films deposition by reactive magnetron sputtering:

- ↳ power density 2W/cm²
- ↳ total pressure: $p_{\text{total}} = 10^{-1}$ Torr
- ↳ plasma mixture: H₂ / Ar, pH₂ / p_{total} = 80 %
- ↳ temperature: 200°C
- ↳ substrates: amorphous SiO₂ (a-SiO₂)
(100)-Si single-crystals
- ↳ target-substrate distance (d)
 - a-SiO₂ substrates: d = 4, 6, 7, 8, 10, 12 cm
films A, B, C, D, E, F
 - (100)-Si: d = 6, 12 cm
films G, H

Aim: quantum confinement, photoluminescence properties

Typical refinement

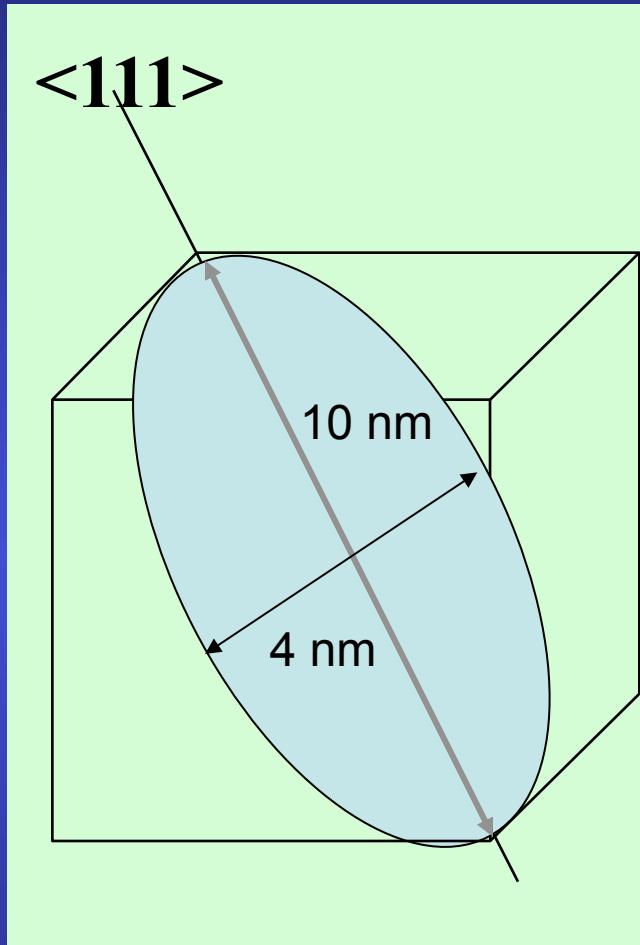


broad, anisotropic diffracted lines, textured samples

Refinement Results

Sample	d (cm)	a (Å)	RX thickness (nm)	Anisotropic sizes (Å)			Texture parameters			Reliability factors (%)			
				<111>	<220>	<311>	Maximum (m.r.d.)	minimum (m.r.d.)	Texture index F ² (m.r.d ²)	RP ₀	R _w	R _B	R _{exp}
A	4	5.4466 (3)	—	94	20	27	1.95	0.4	1.12	1.72	4.0	3.7	3.5
B	6	5.4439 (2)	711 (50)	101	20	22	1.39	0.79	1.01	0.71	4.9	4.3	4.2
C	7	5.4346 (4)	519 (60)	99	40	52	1.72	0.66	1.05	0.78	4.3	4.0	3.9
D	8	5.4461 (2)	1447 (66)	100	22	33	1.57	0.63	1.04	0.90	5.5	4.6	4.5
E	10	5.4462 (2)	1360 (80)	98	20	25	1.22	0.82	1.01	0.56	5.0	3.9	4.0
F	12	5.4452 (3)	1110 (57)	85	22	26	1.59	0.45	1.05	1.08	4.2	3.5	3.7
G	6	5.4387 (3)	1307 (50)	89	22	28	1.84	0.71	1.01	1.57	5.2	4.7	4.2
H	12	5.4434 (2)	1214 (18)	88	22	24	2.77	0.50	1.12	2.97	5.0	4.5	4.3

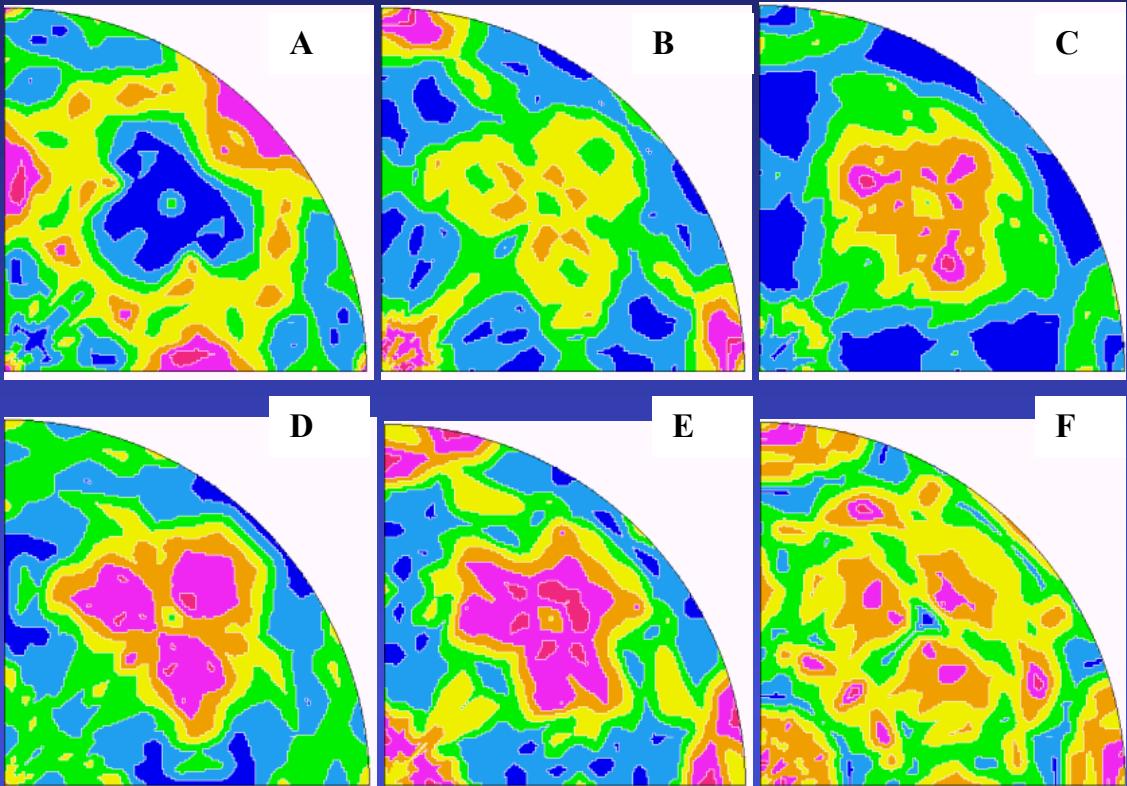
Mean anisotropic shape



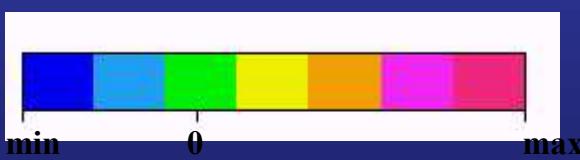
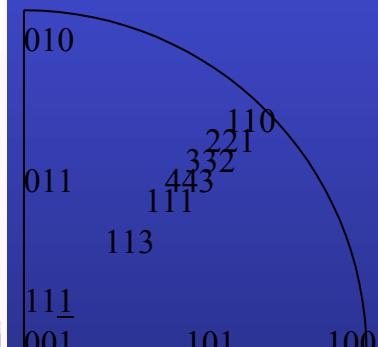
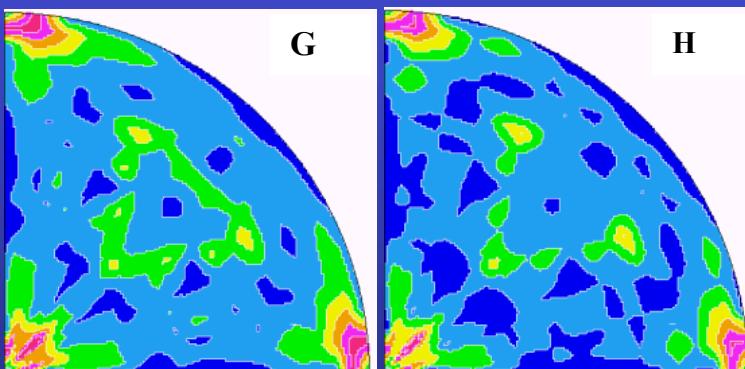
Schematic of the mean crystallite shape for Sample D represented in a cubic cell, as refined using the Popa approach and exhibiting a strong elongation along $<111>$, and TEM image

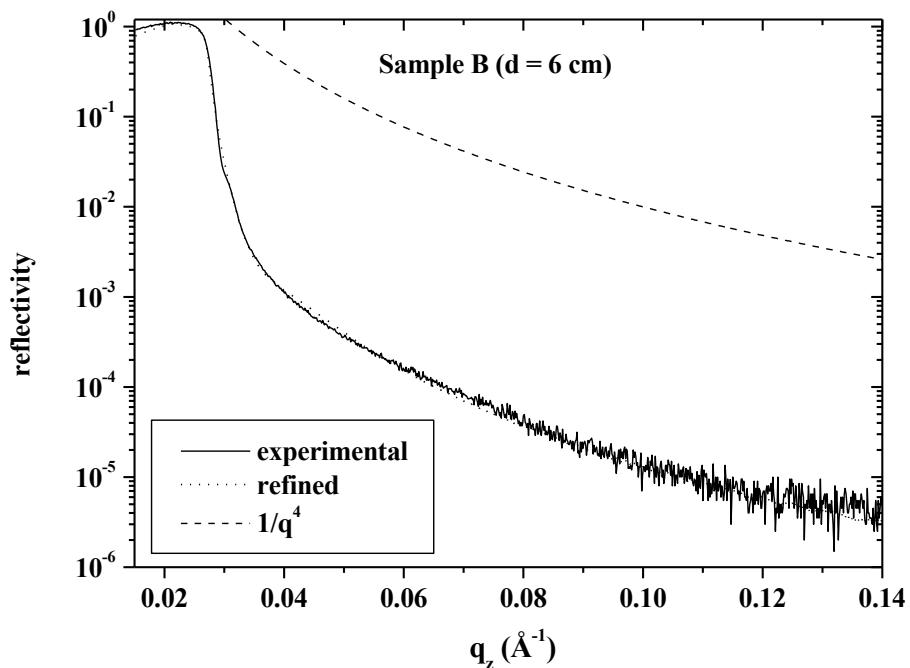
001 Inverse Pole Figures

a-SiO₂



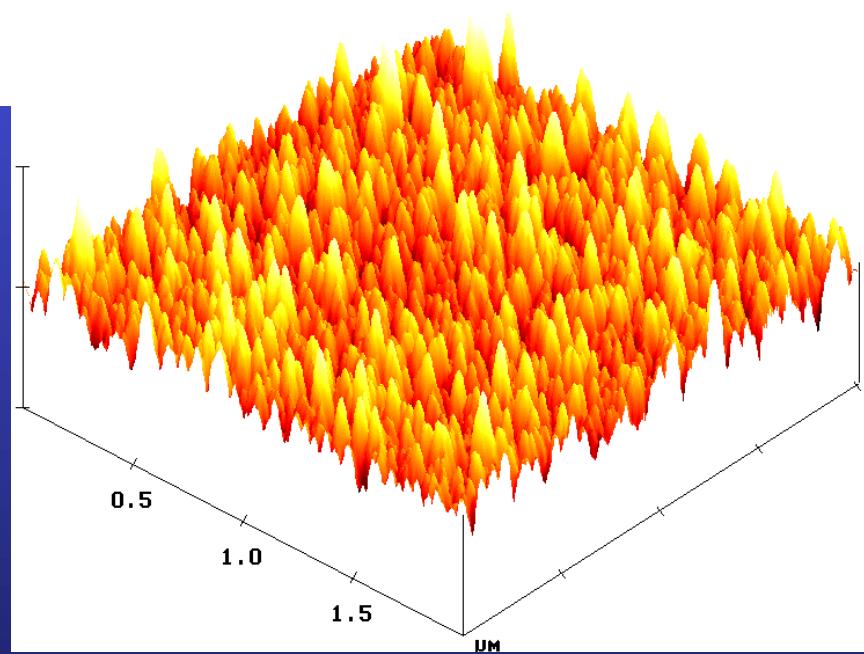
(100)-Si

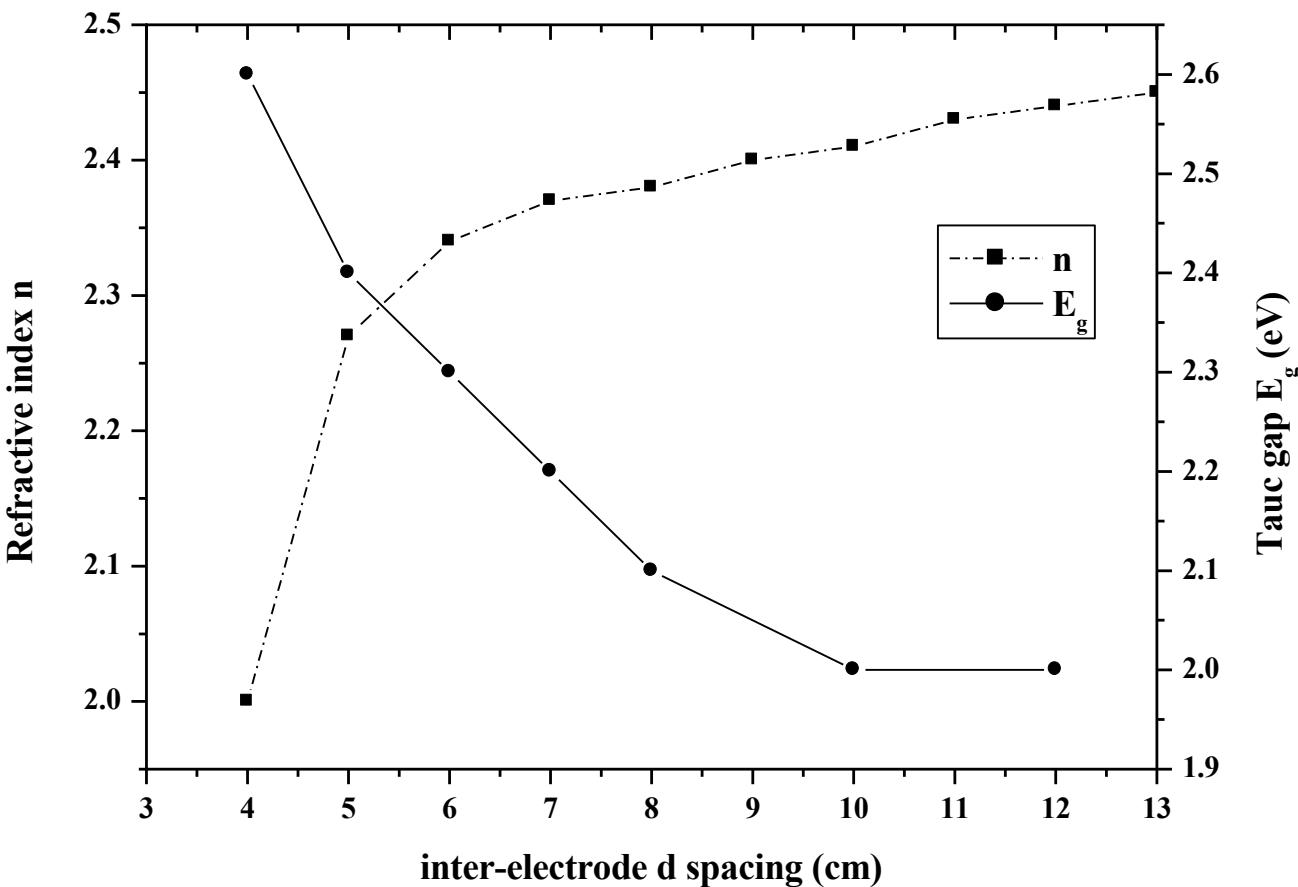




XRR:
Roughness
governed

AFM:
homogeneous
roughness

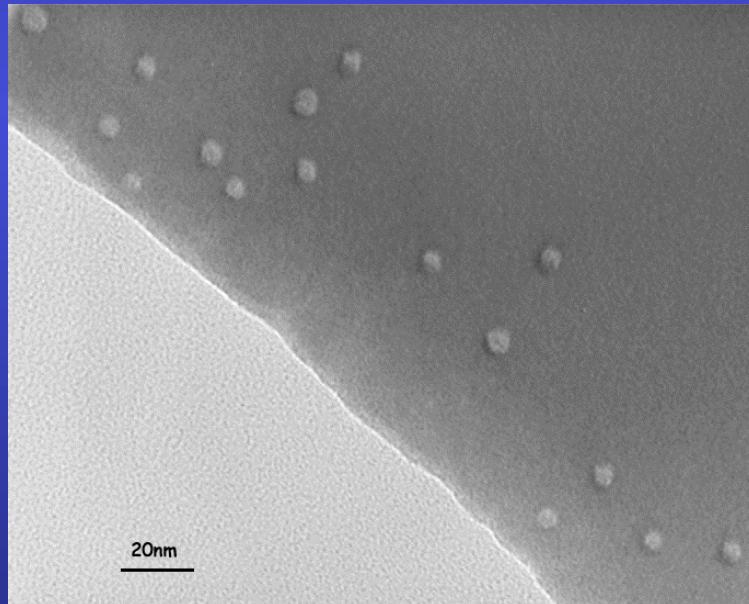




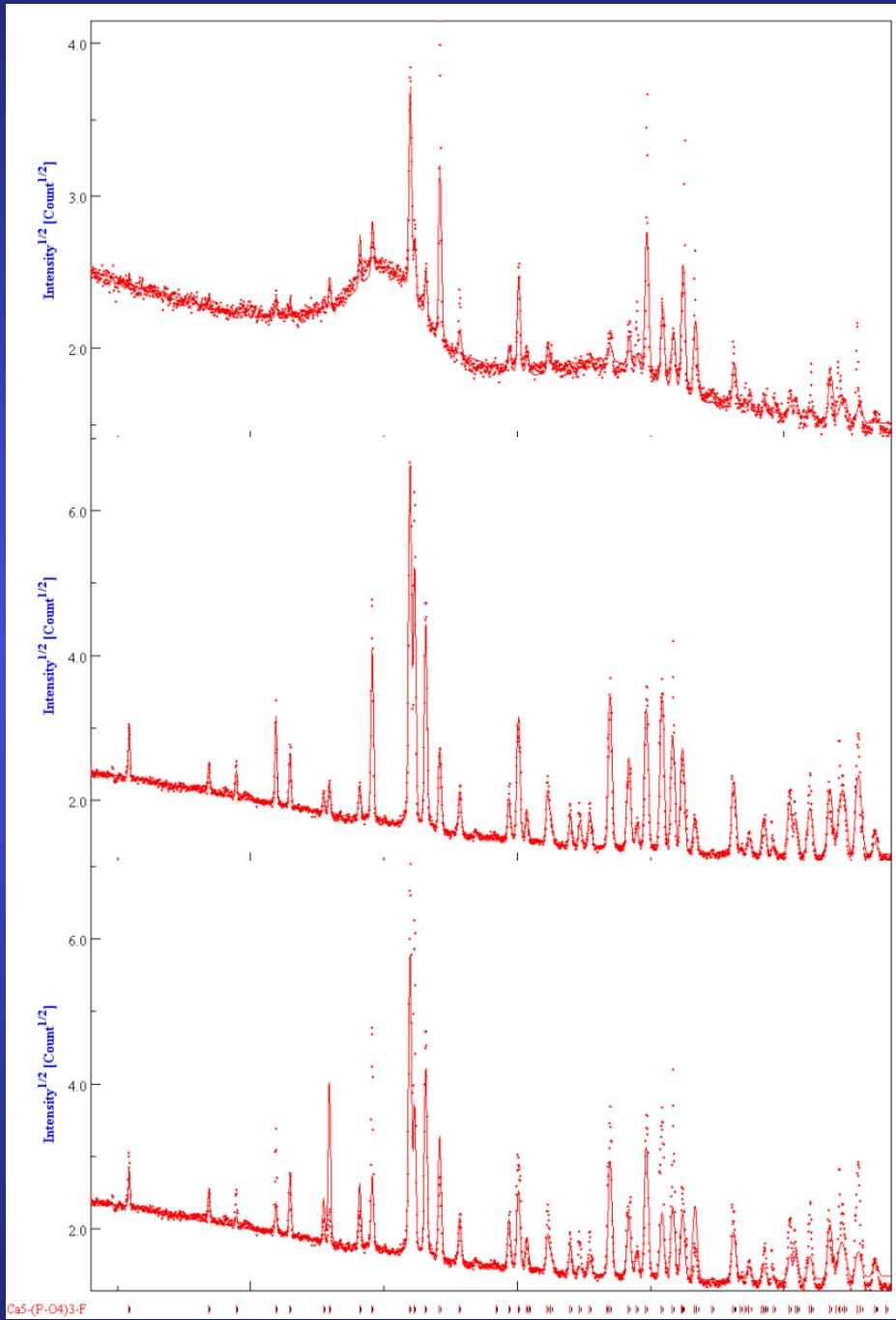
☞ Refractive index linked to film porosities:
Larger target-sample distances: increased compacity due to lower nanopowder filling

Irradiated FluorApatite (FAp) ceramics

Self-recrystallisation under irradiation, depending on SiO_4 / PO_4 ratio (FAp / Nd-Britholite) and on irradiating species



TEM of FAp
irradiated with 70
MeV, 10^{12} Kr cm $^{-2}$
ions



texture corrected,
 10^{13} Kr cm⁻²

Virgin, with texture
correction

Virgin, no texture
correction

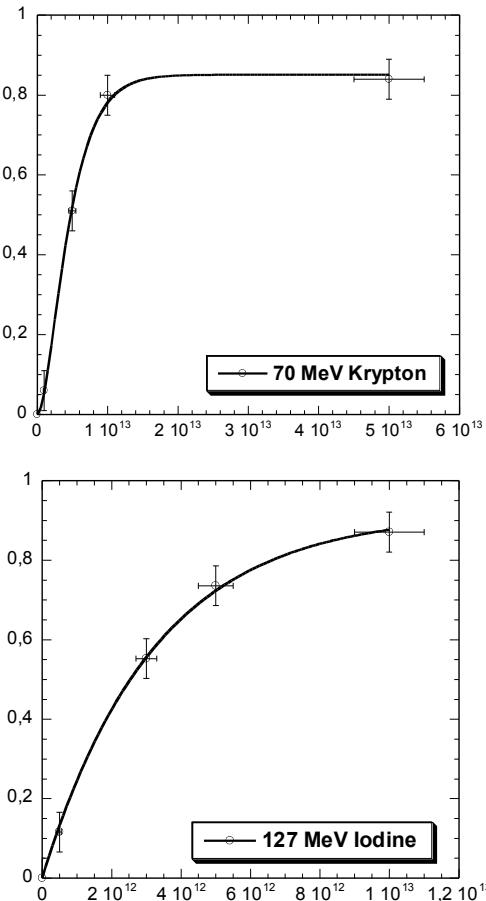
Fluence (ions.cm ⁻²)	Vc/V (%)	A (Å)	c (Å)	$\langle t \rangle$ (nm)	$\Delta a/a_0$ (%)	$\Delta c/c_0$ (%)	R _w (%)	R _B (%)
0	100	9.3365(3)	6.8560(5)	294(22)	-	-	14.6	9.1
Kr								
10^{11}	100	-	-	-	-	-		
10^{12}	100	-	-	-	-	-		
5.10^{12}	49(1)	9.3775(9)	6.8912(8)	294(20)	0.44	0.53	24	15
10^{13}	20(1)	9.4236(5)	6.9105(5)	291(20)	0.94	0.82	9.9	6
5.10^{13}	14(1)	9.3160(4)	6.8402(5)	294(22)	-0.21	-0.22	10.5	5.9
I								
10^{11}	-	-	-	-	-	-		
5.10^{11}	86(2)	9.3603(3)	6.8790(5)	90(10)	0.26	0.35	23.9	15.1
10^{12}	-	-	-	-	-	-		
3.10^{12}	47(2)	9.3645(3)	6.8840(5)	91(6)	0.30	0.42	13.3	9
5.10^{12}	29.2(5)	9.3765(5)	6.8881(6)	77(11)	0.44	0.48	10.4	7.3
10^{13}	13.2(2)	9.3719(4)	6.8857(6)	82(9)	0.38	0.45	6.7	4.9

Single impact model associated to crystal size reduction

Cell parameters and volume increase, then relax

Amorphisation / recrystallisation competition: single or double impact

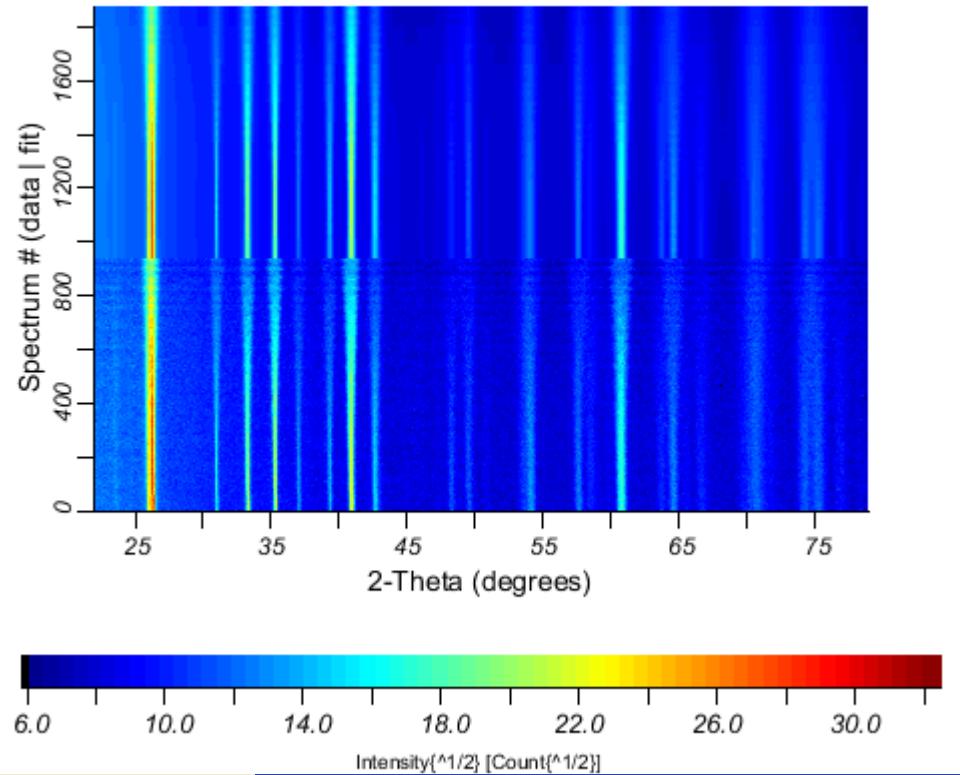
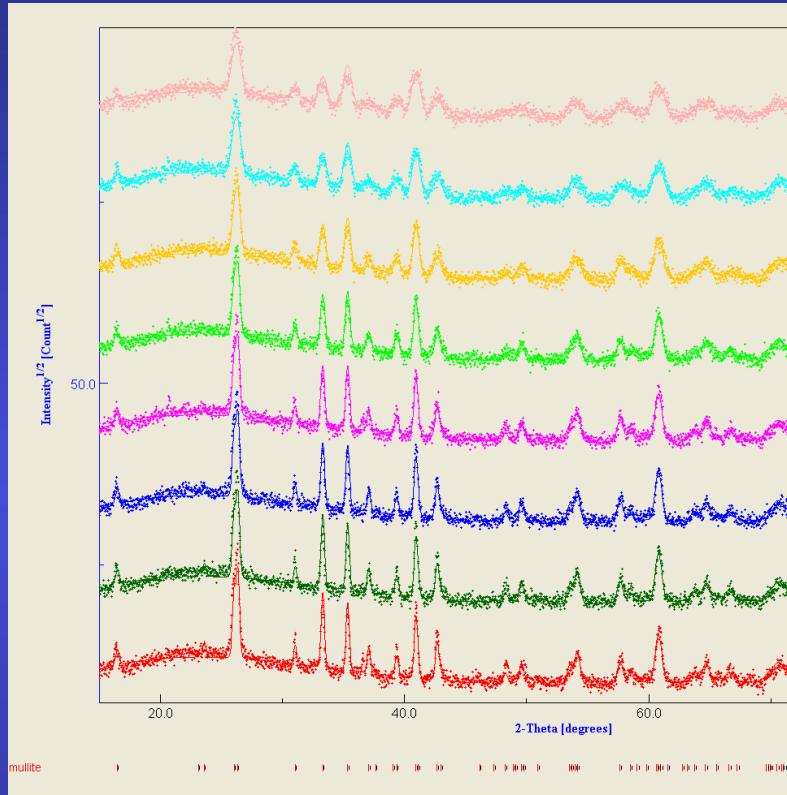
Amorphous/crystalline volume fraction (damaged fraction $F_d = V_a / V$) as determined by x-ray diffraction



B

Fitting parameters	Krypton		Iodine
	Single impact $F_d = B(1 - \exp(-A\Phi_t))$	Double impact $F_d = B(1 - (1 + A\Phi_t) \exp(-A\Phi_t))$	Single impact $F_d = B(1 - \exp(-A\Phi_t))$
$A = \pi R^2 (\text{cm}^2)$	$1.85 \pm 0.15 10^{-13}$	$4.1 \pm 0.15 10^{-13}$	$3.3 \pm 0.15 10^{-13}$
Radius R (nm)	2.4 ± 0.2	3.6	3.2
B (Max.damage rate)	0.87	0.85 ± 0.2	0.92 ± 0.2
χ^2	0.013	0.0006	0.0004

Mullite-silica composites

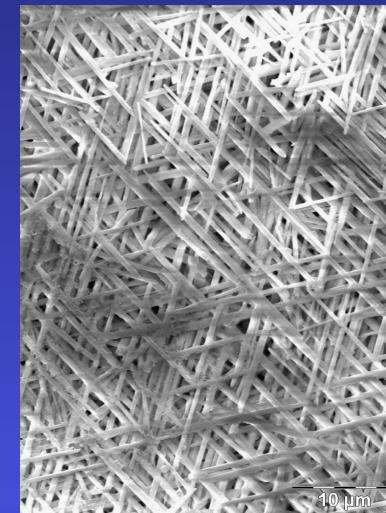
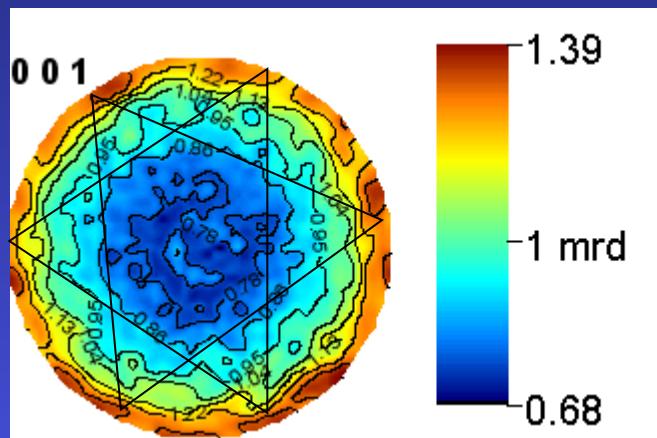


ODF: $R_w = 4.87\%$, $R_B = 4.01\%$

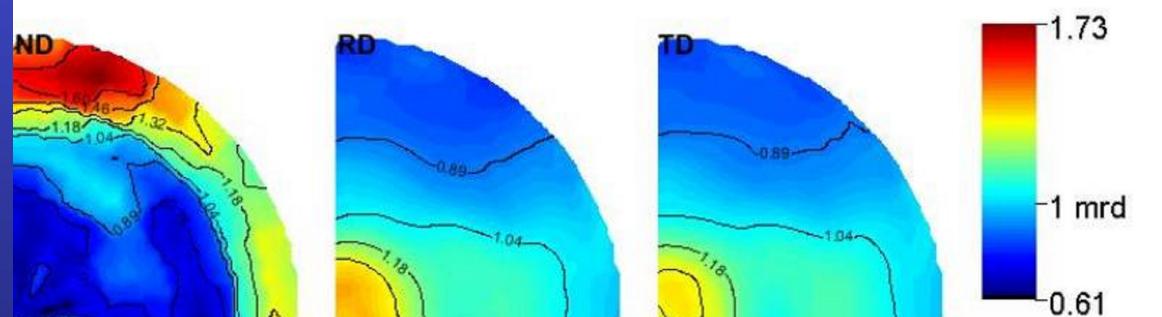
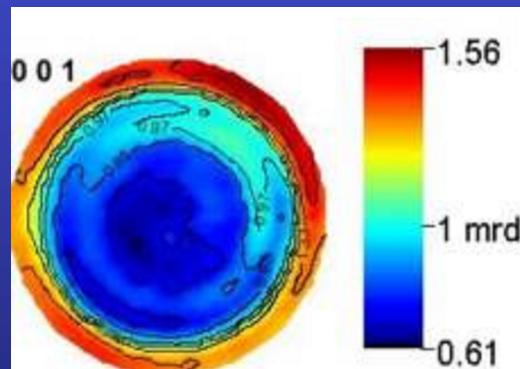
Rietveld: $R_w = 12.90\%$, GoF = 1.77

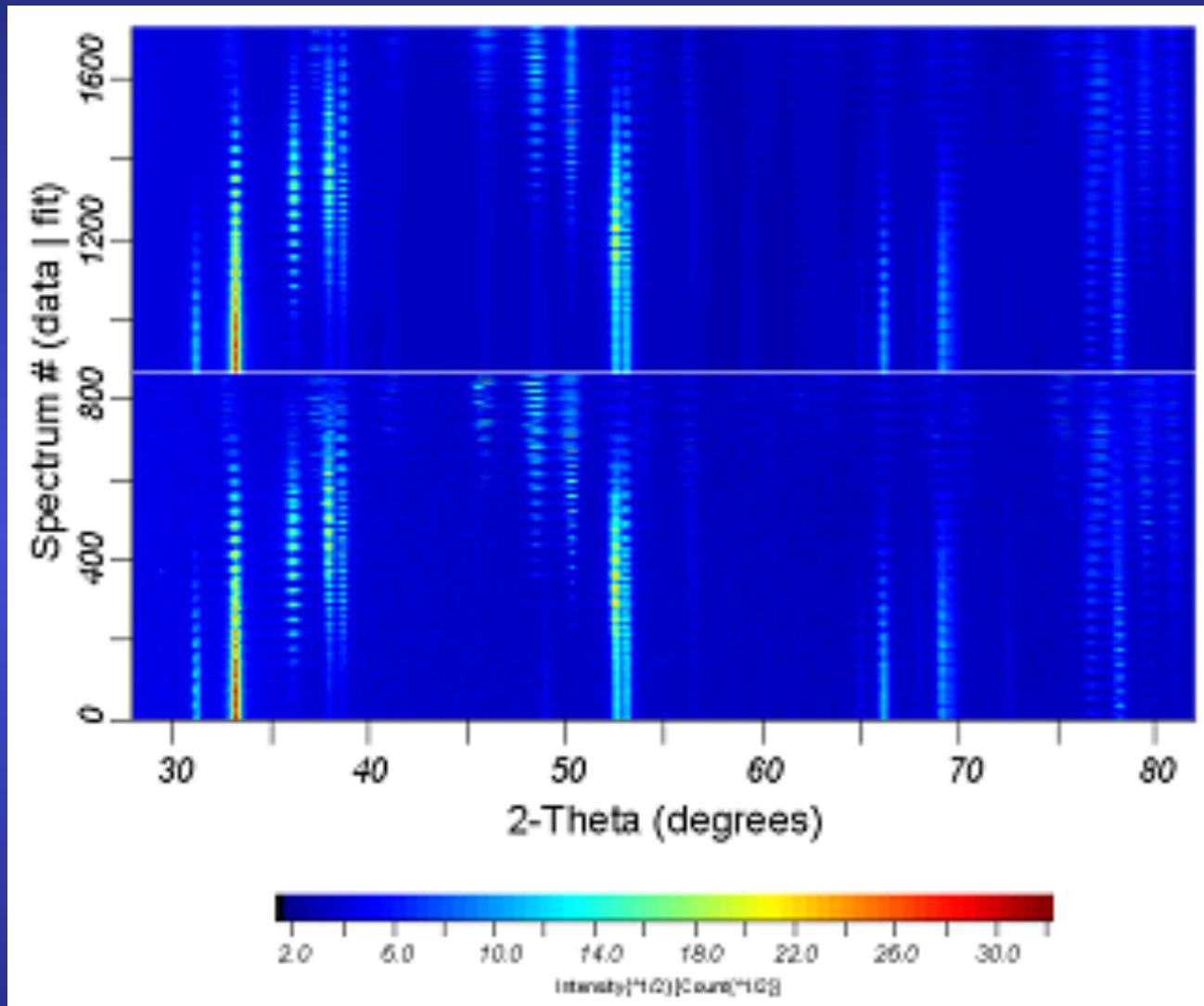
Mullite: $a = 7.56486(5)\text{ \AA}$; $b = 7.71048(5)\text{ \AA}$; $c = 2.89059(1)\text{\AA}$

Uniaxially pressed



Centrifugated





refined

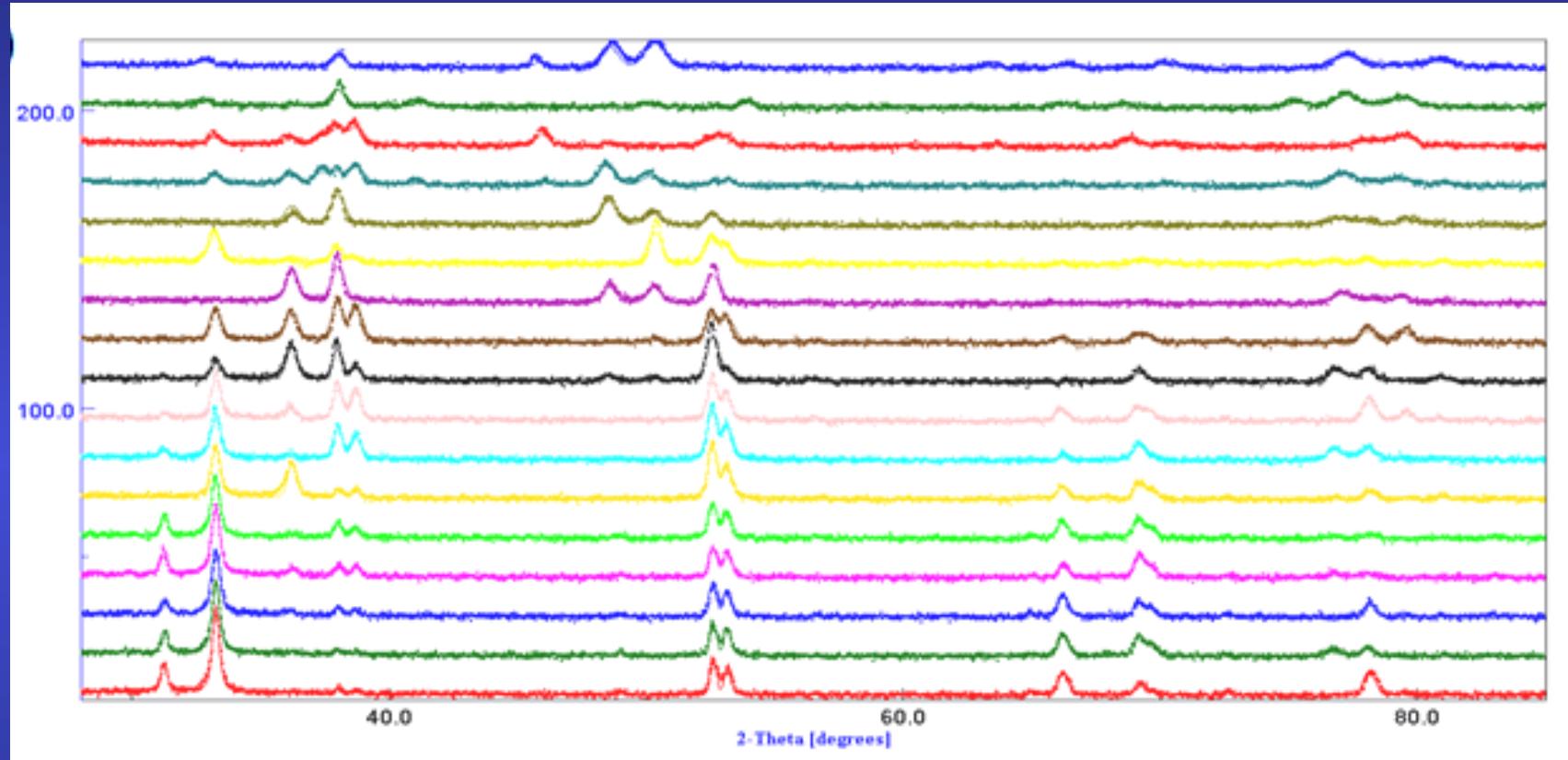
experiments

GoF:1,72

Rw: 28,0%

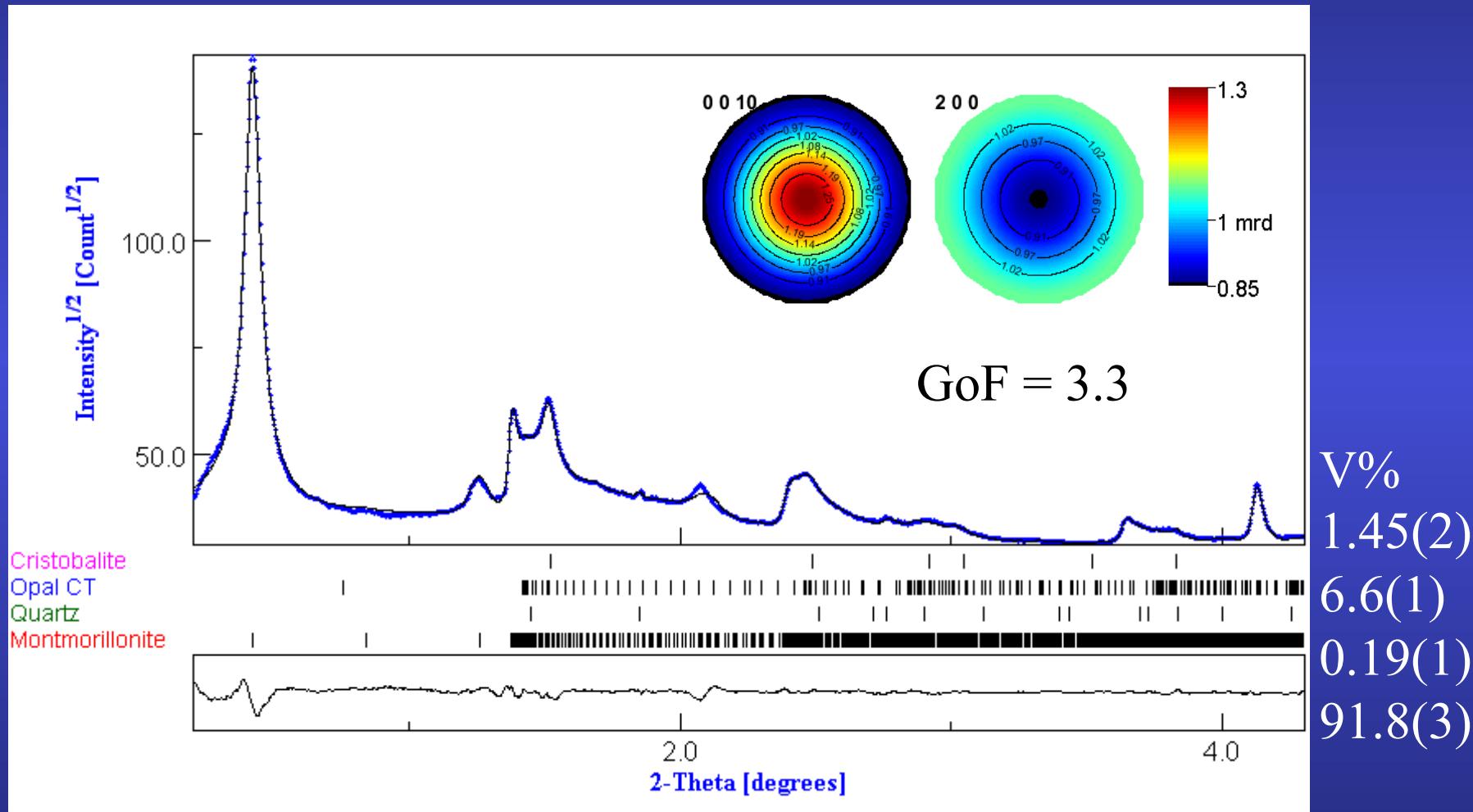
Rexp:21,3%

for all (χ, φ) sample orientations



IRC layer of *Charonia lampas lampas* for selected (χ, φ) sample orientations

Turbostratic phyllosilicate aggregates



Specular reflectivity: $\mathbf{q}=(0,0,z)$

- Fresnel:

$$R(\mathbf{q}) = \left| \frac{q_z - \sqrt{q_z^2 - q_c^2 + \frac{32i\pi^2\beta}{\lambda^2}}}{q_z + \sqrt{q_z^2 - q_c^2 + \frac{32i\pi^2\beta}{\lambda^2}}} \right|^2 \delta q_x \delta q$$

- matrix:

$$R^{flat} = \frac{r_{0,1}^2 + r_{1,2}^2 + 2r_{0,1}r_{1,2} \cos 2k_{Z,1}h}{1 + r_{0,1}^2 r_{1,2}^2 + 2r_{0,1}r_{1,2} \cos 2k_{Z,1}h}$$

- Born approximation:
Electron Density Profile

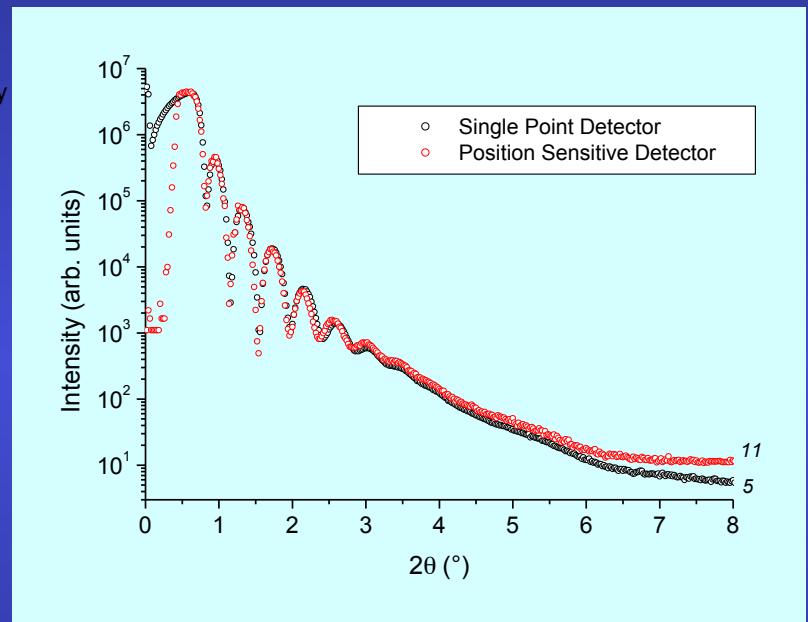
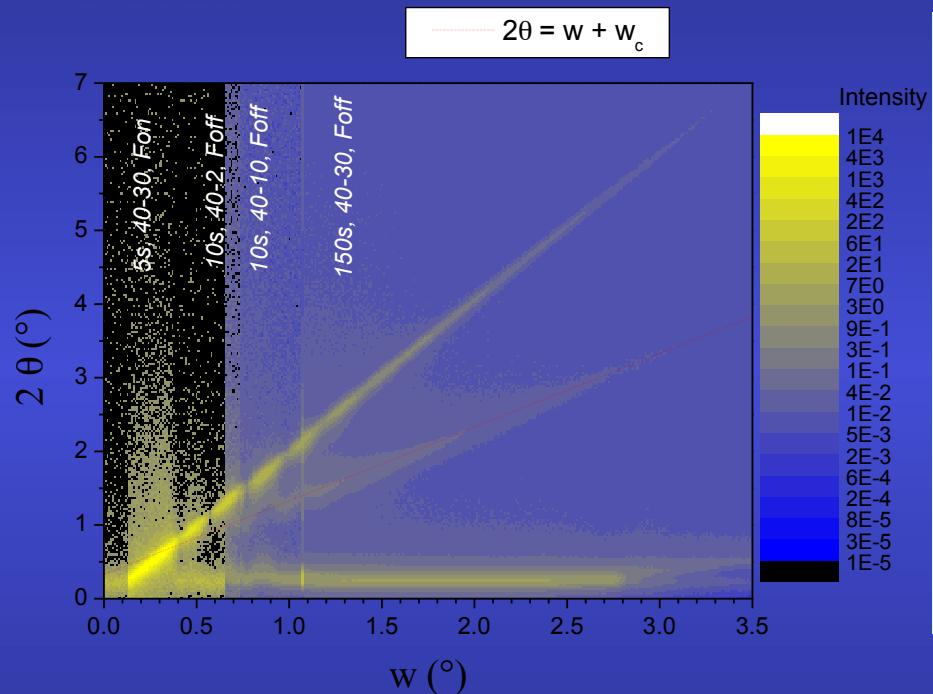
$$R(q_z) = r \cdot r^* = R_F(q_z) \left| \frac{1}{\rho_s} \int_{-\infty}^{+\infty} d\rho(z) e^{iq_z z} dz \right|^2$$

- Roughness:

$$R^{rough}(q_z) = R(q_z) \exp(-q_{z,0} q_{z,1} \sigma^2) \quad \text{Low-angles (reflectivity)}$$

$$S_R = 1 - p \exp(-q) + p \exp\left(\frac{-q}{\sin \theta}\right) \quad \text{high-angle (Suortti)}$$

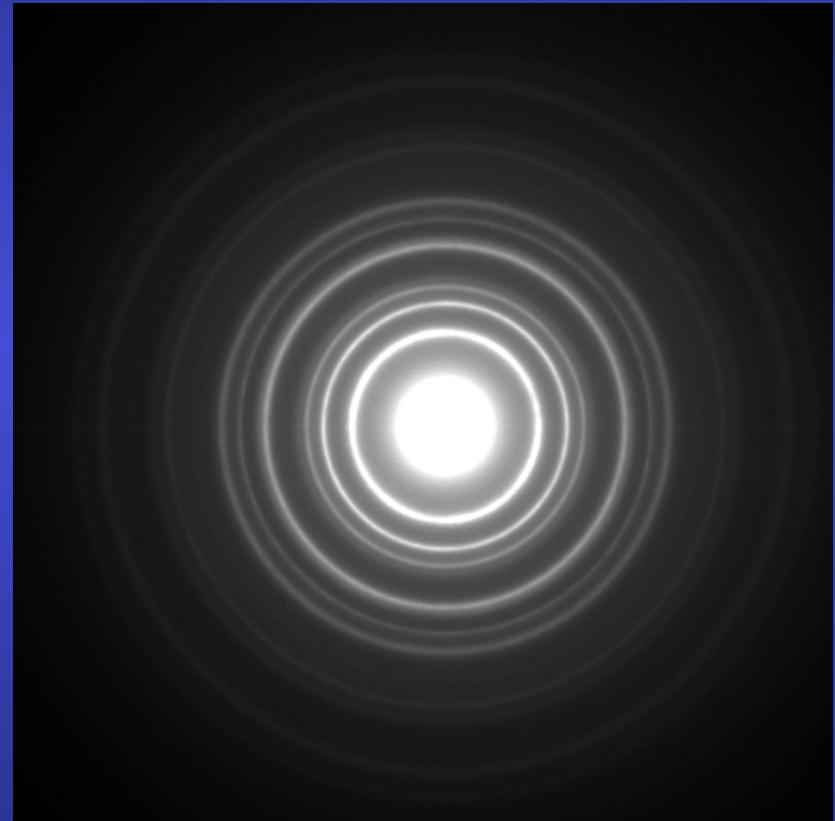
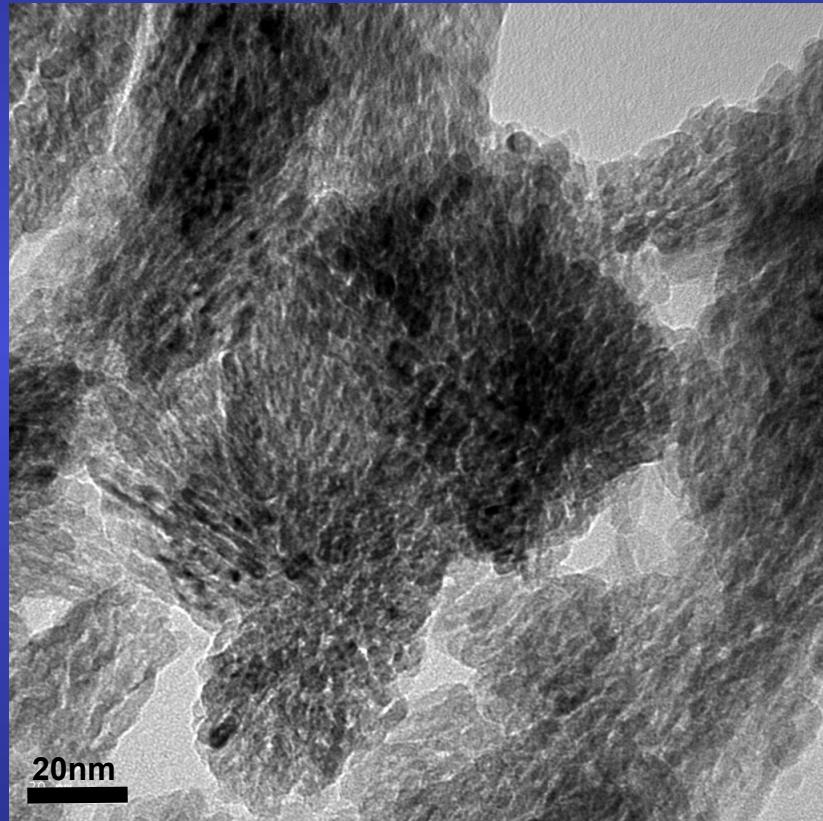
CPS scans

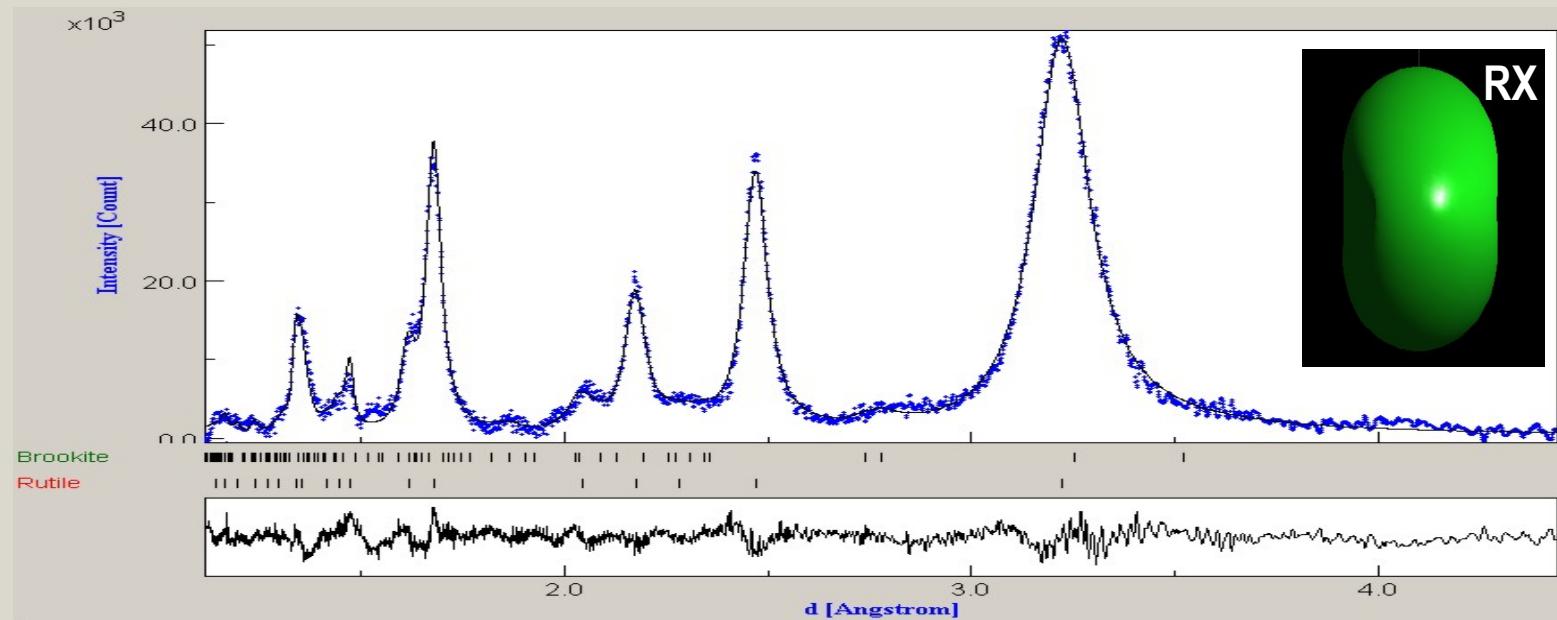


Useful for having both specular and off-specular signals in one scan

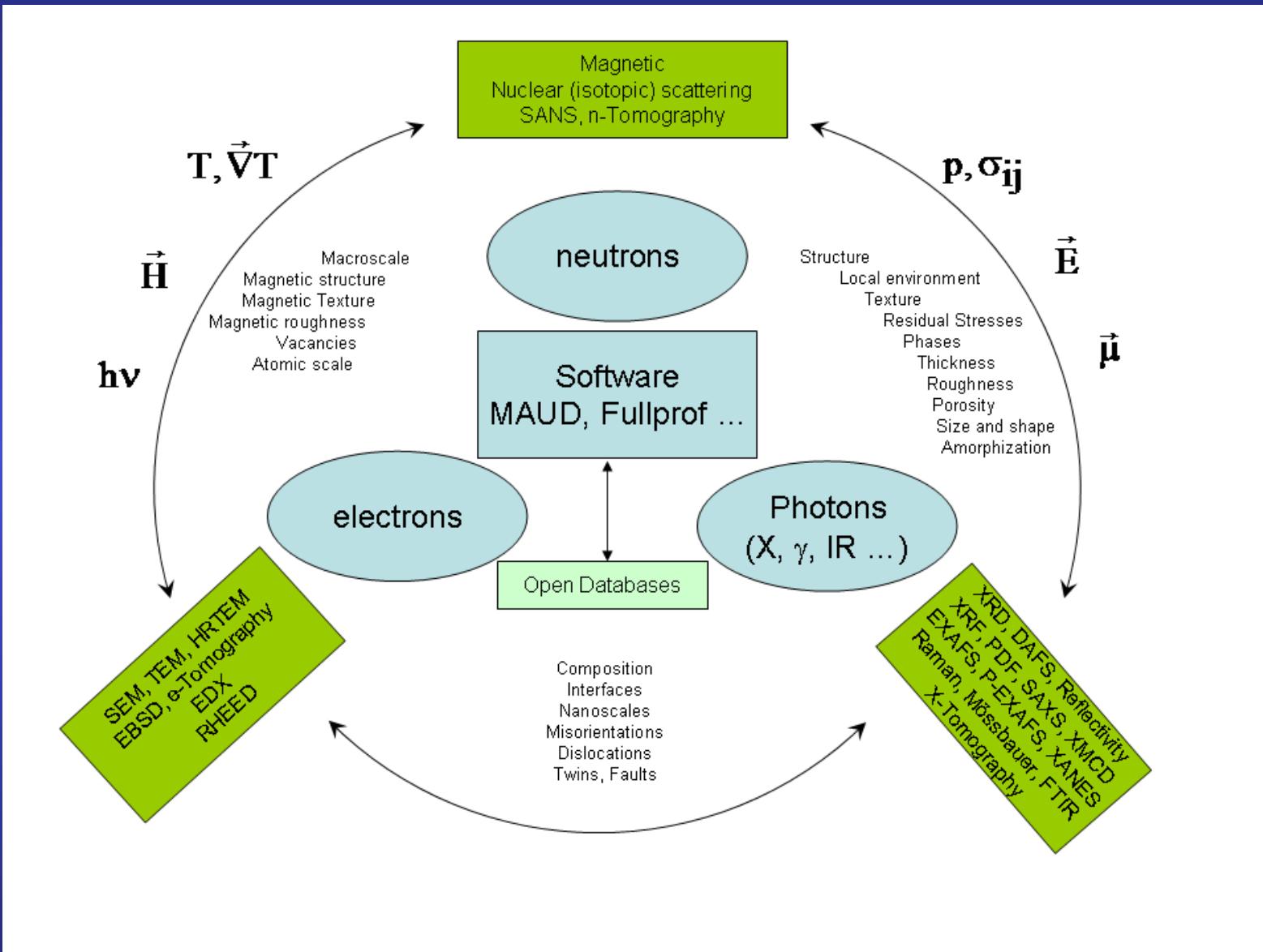
Microstructure of nanocrystalline materials: TiO_2 rutile ⁽¹⁾

► quantitative analysis of electron diffraction ring pattern ?





Why not more ?



Conclusions

- a) A lot of dilemma are only apparent
- b) Texture helps to resolve them: good for real samples
- c) Anisotropy favours higher resolutions
- d) Combined analysis may be a solution, unless you can destroy your sample or are not interested in macroscopic anisotropy ...
- e) If you think you can destroy it, perhaps think twice
- f) more information is always needed: why not more?
- g) Combined Analysis (D. Chateigner Ed), Wiley-ISTE 2010